

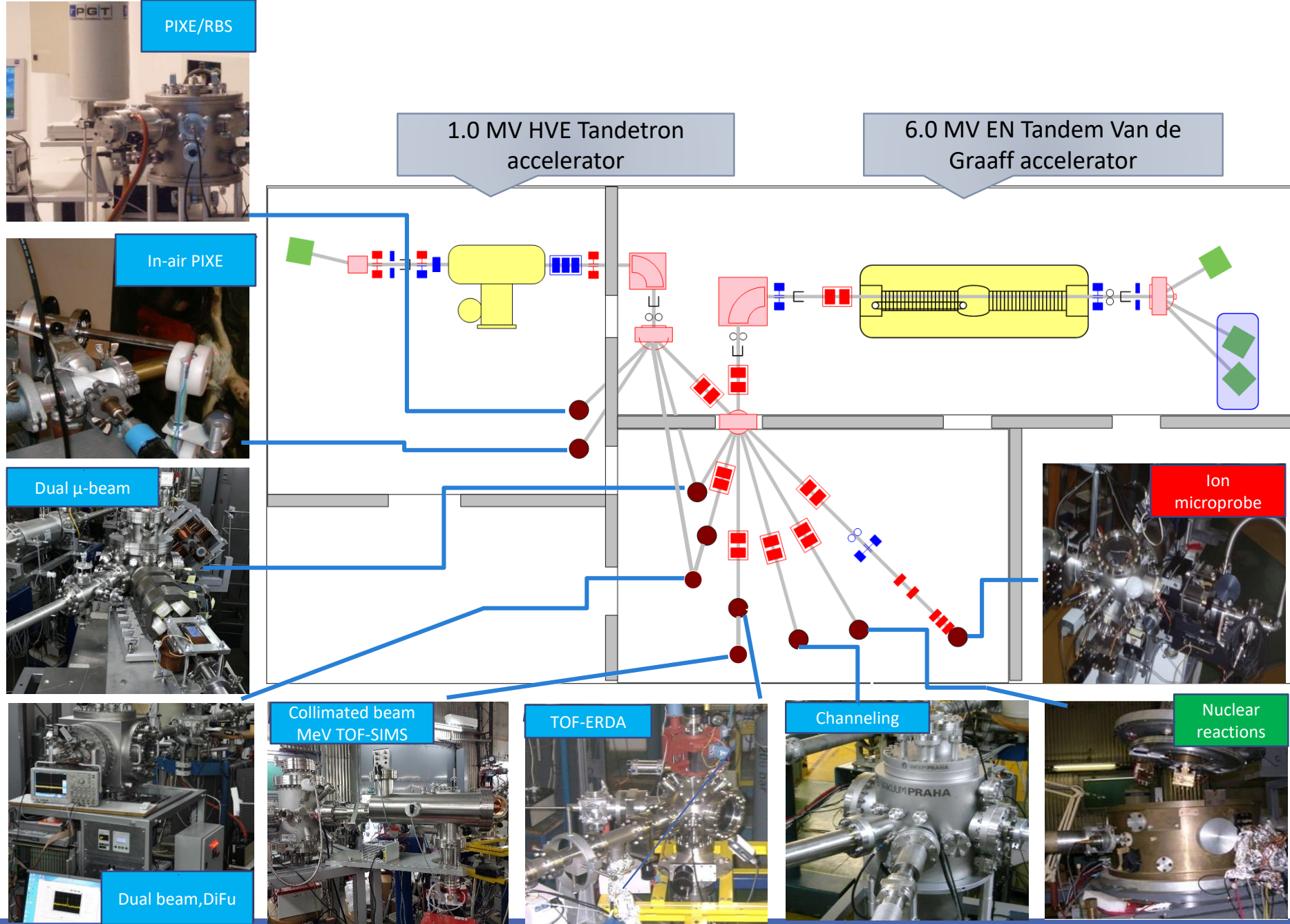
Time-of-flight methods in ion beam analysis

MARKO BRAJKOVIĆ, ZDRAVKO SIKETIĆ, MARKO BARAC, IVANČICA BOGDANOVIĆ RADOVIĆ
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EUNPC22, SANTIAGO DE COMPOSTELA, OCTOBER 2022



RBI ACCELERATOR FACILITY

Currently: protons up to 8 MeV,
and heavy ions up to 30 MeV
from the VDG accelerator

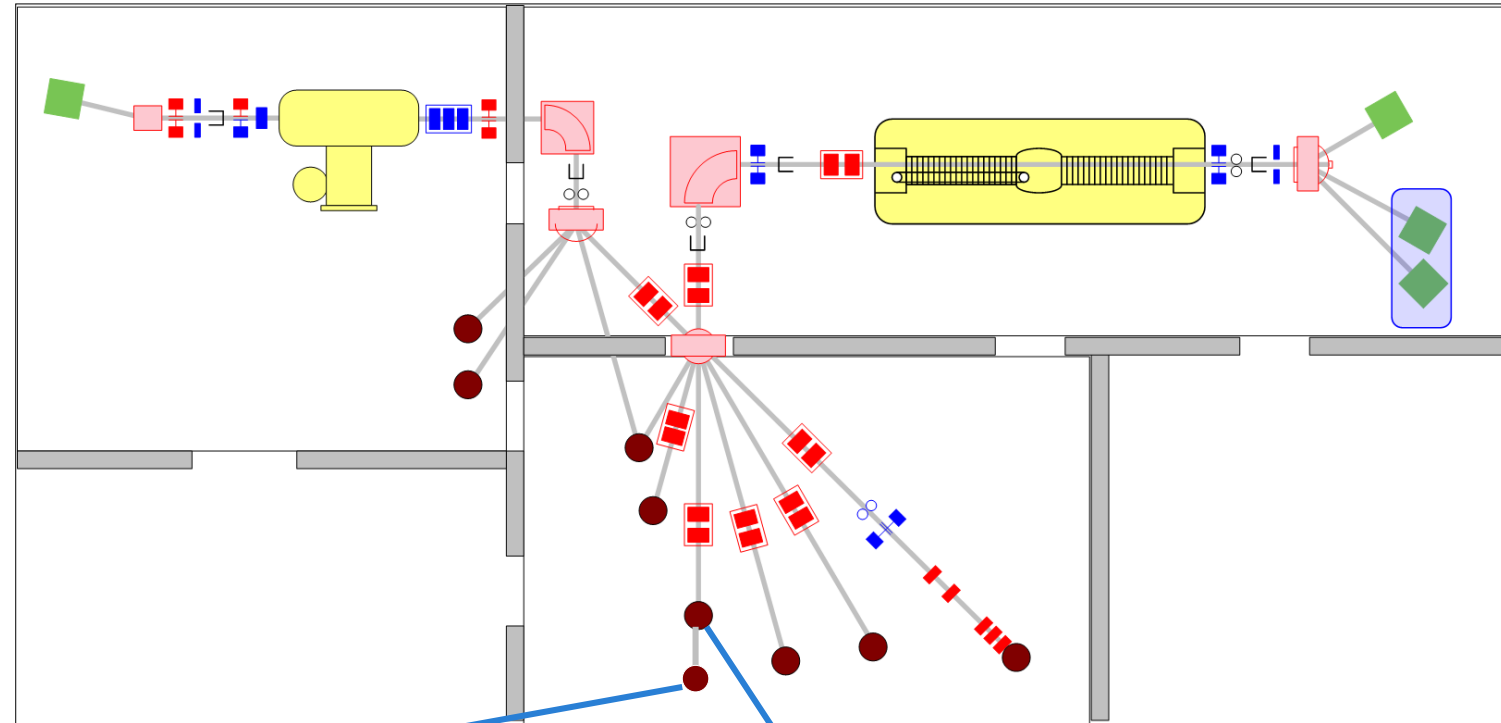


HEAVY ION BEAM TECHNIQUES

Most IBA techniques use protons: PIXE, RBS, PIGE, IBIC.

Heavy ions vs protons:

- Production of recoils and secondary particles
- High stopping power



MeV TOF SIMS
Time-of-Flight Secondary
Ion Mass Spectrometry
organic samples



TOF ERDA
Time-of-Flight Elastic
Recoil Detection Analysis
inorganic films



TOF ERDA

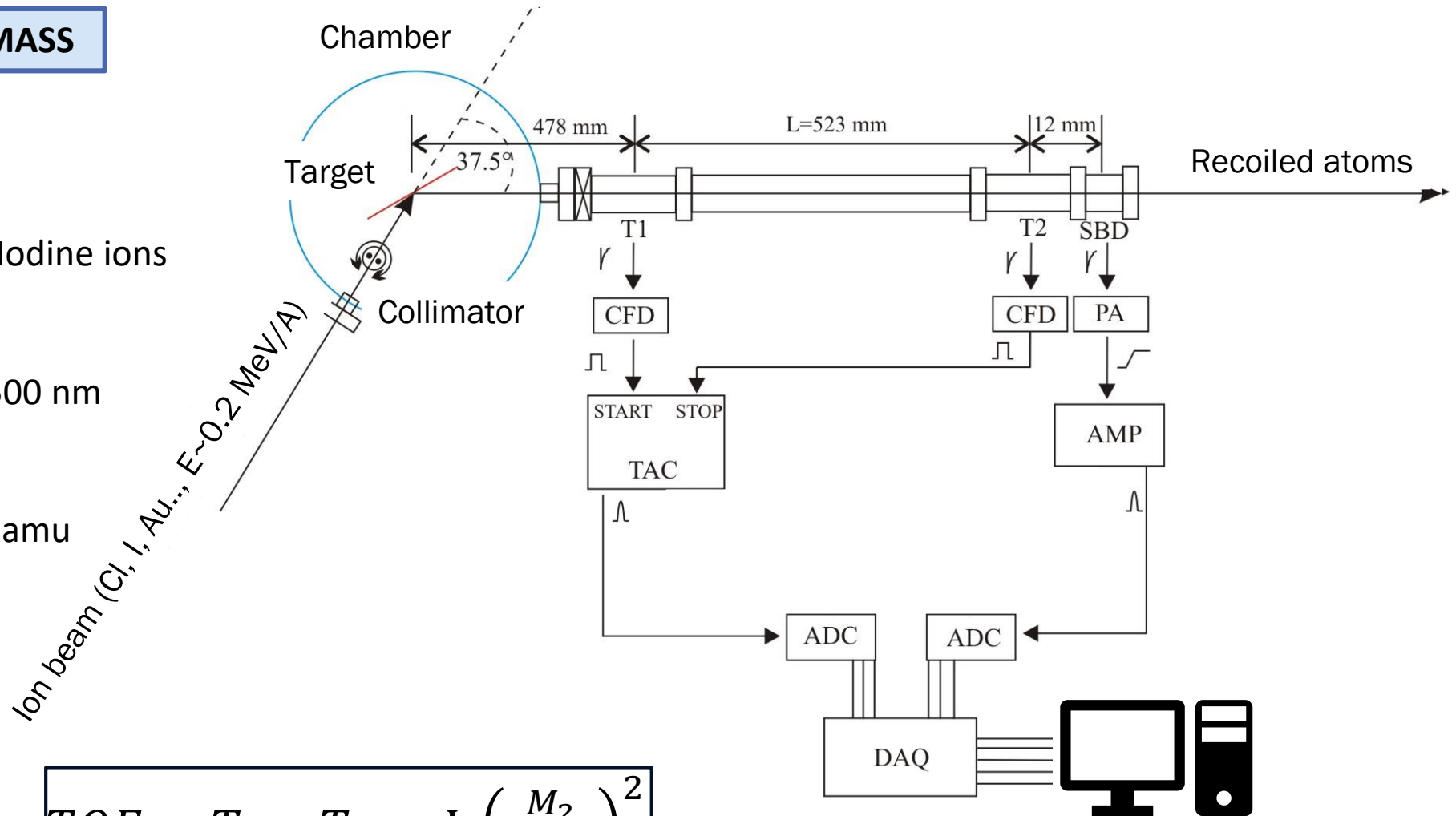
Time-of-Flight Elastic Recoil Detection Analysis

SEPARATION OF ELEMENTS BY MASS

Heavy ion beam – e.g. 23 MeV Iodine ions

- sensitivity $10^{15} / \text{cm}^2$
- 2 nm depth resolution, up to 500 nm probe depth
- all elements are resolved
- Resolution $< 1 \text{ amu}$ for $m < 40 \text{ amu}$

- E and TOF measured
- cross sections, stopping powers known



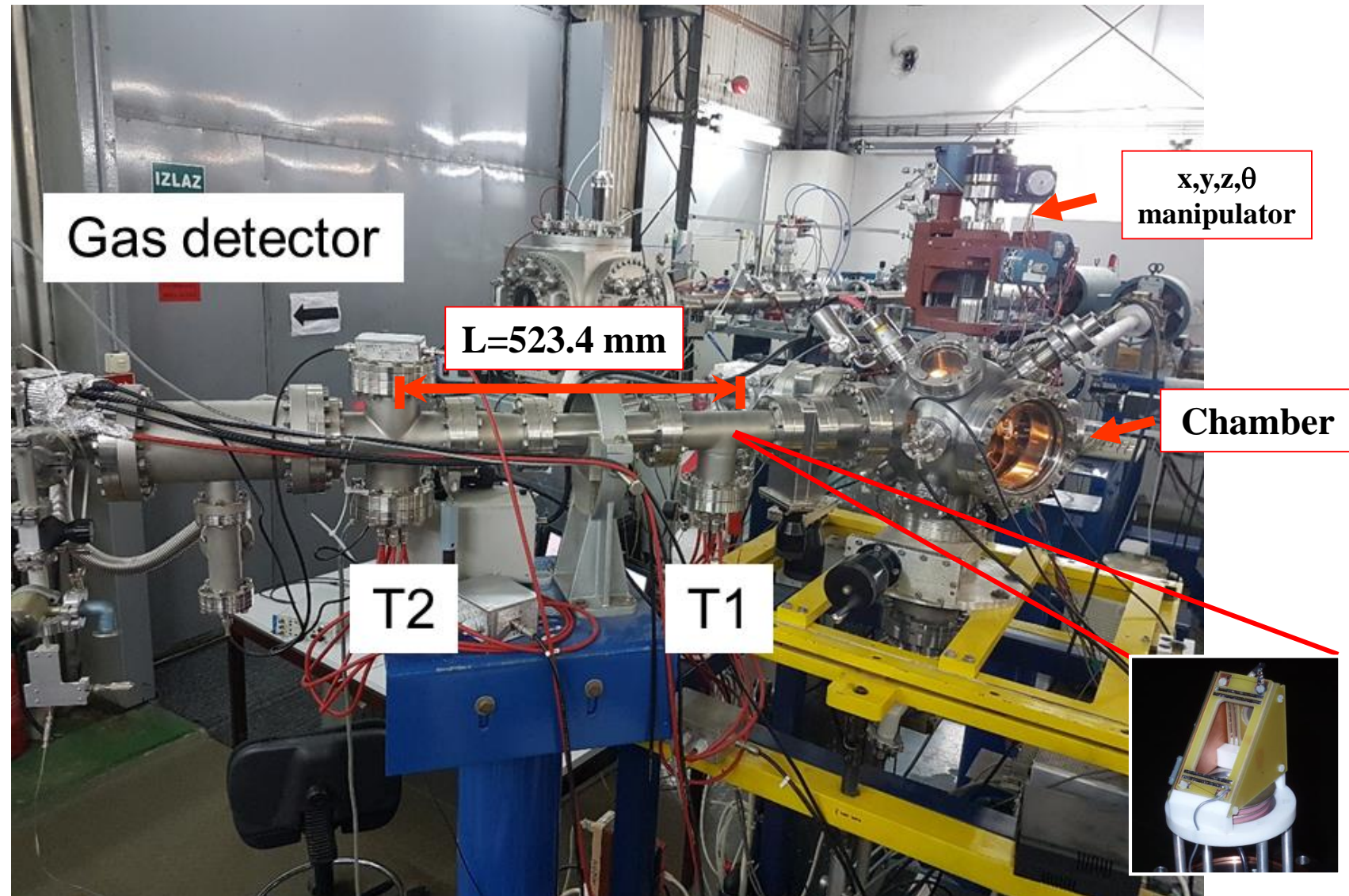
$$TOF = T_1 - T_2 = L \left(\frac{M_2}{2KE_0} \right)^2$$

Depth profiling of few 100 nm thick samples
Depth resolution up to ~1 nm at the surface

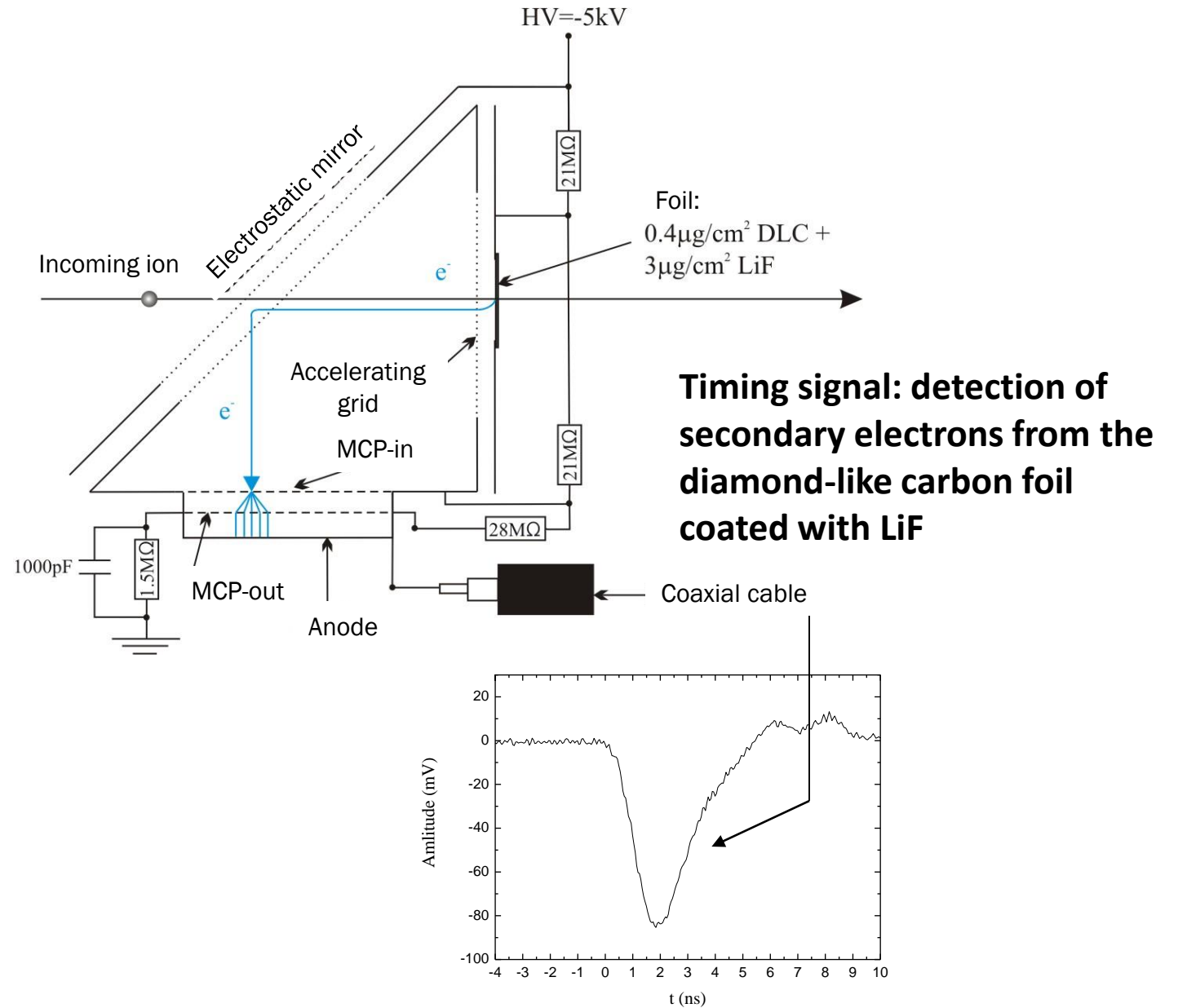
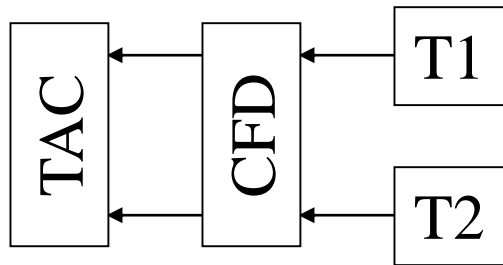
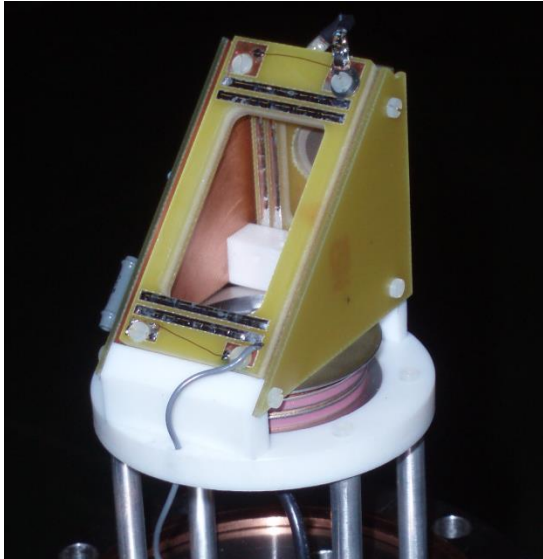
TOF ERDA: SETUP

GID: better energy resolution than particle silicon detectors + radiation hardness

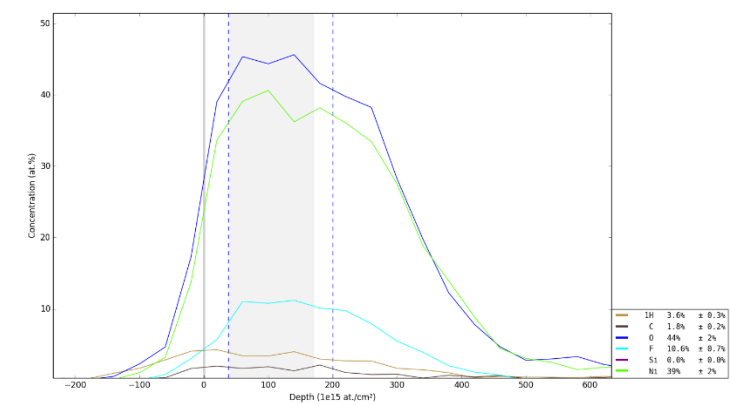
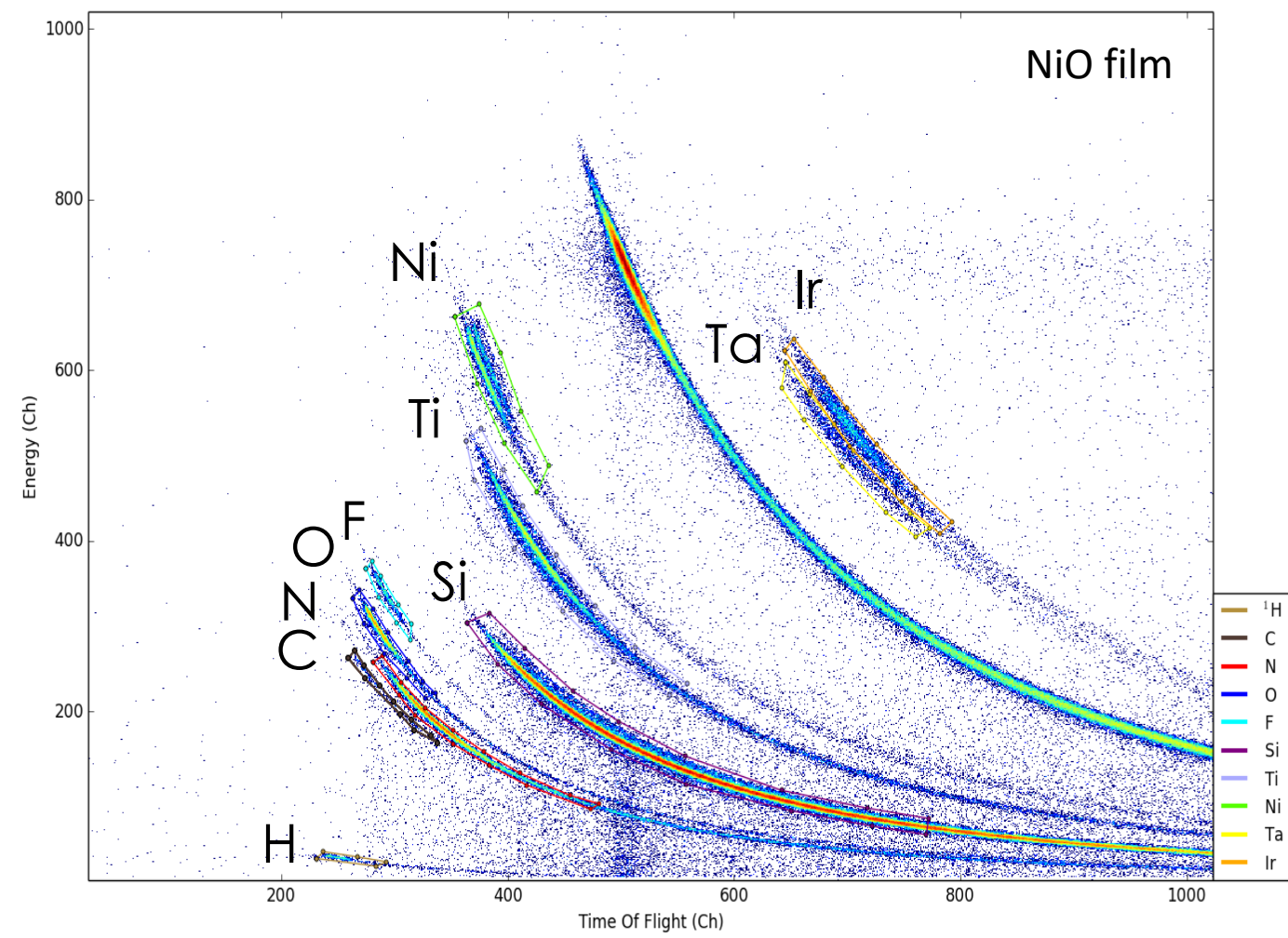
Z. Siketić, N. Skukan and I. Bogdanović Radović "A gas ionisation detector in the axial (Bragg) geometry used for the time-of-flight elastic recoil detection analysis", Review of Scientific Instruments 86, 083301 (2015)



TOF ERDA: SETUP – TIMING GATES



TOF ERDA APPLICATION – Quality control of production proces



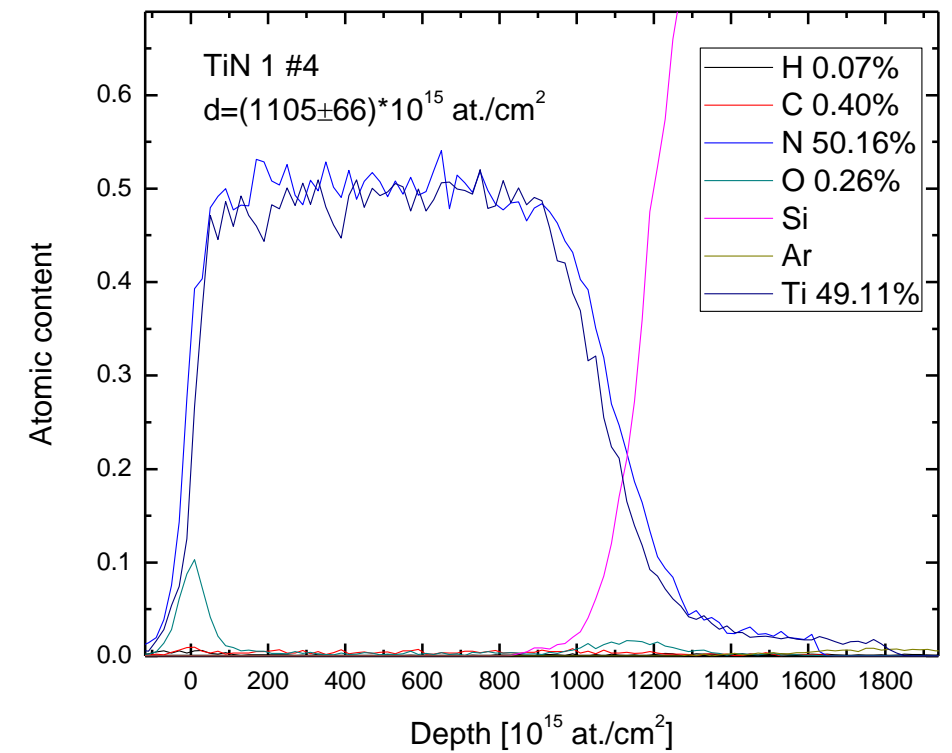
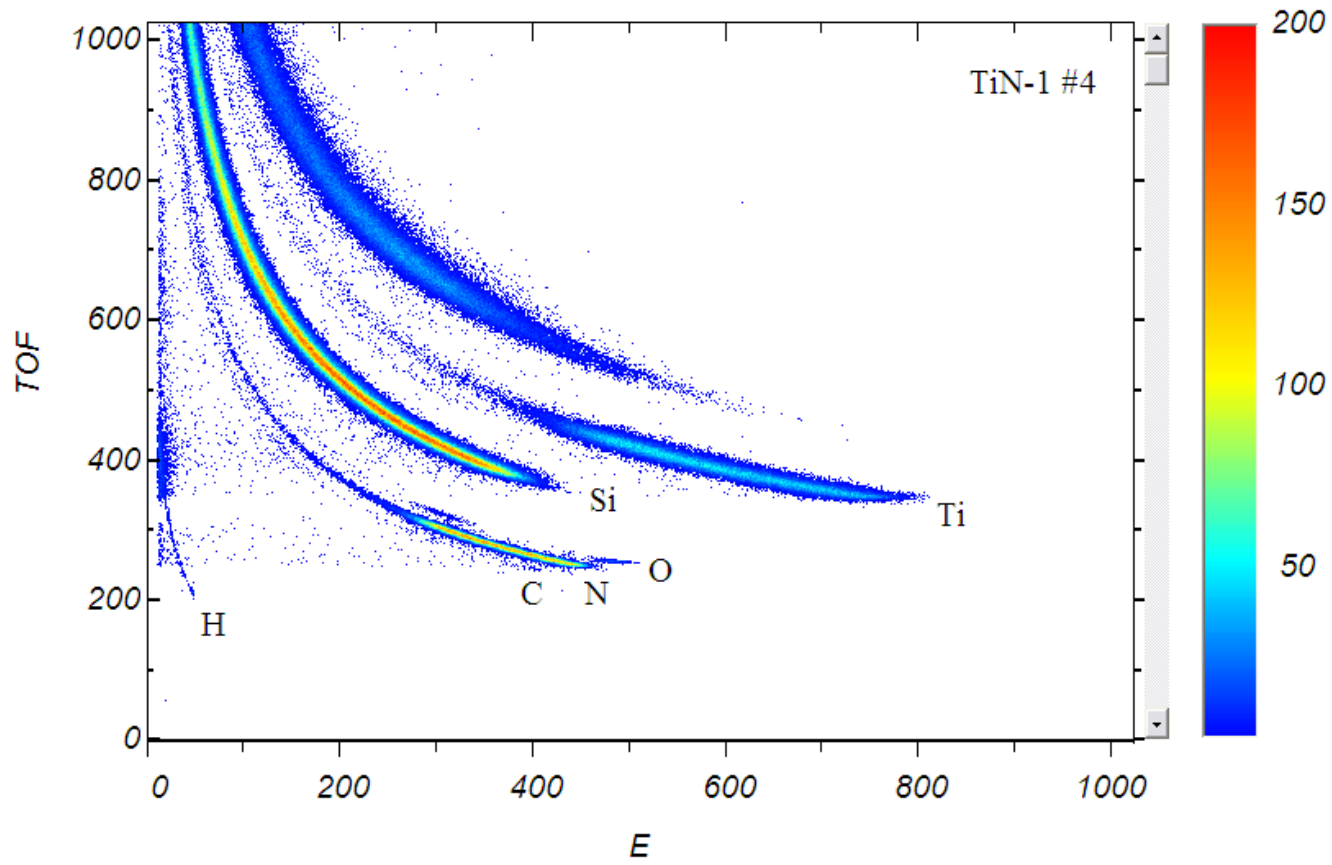
Element	Total Number of 10 ¹⁵ at/cm ²
H	15.2
C	6.6
O	158.7
F	33.5
Ni	141.8

Flourine contamination found

TOF ERDA APPLICATION – Thin film analysis

Sample: TiN

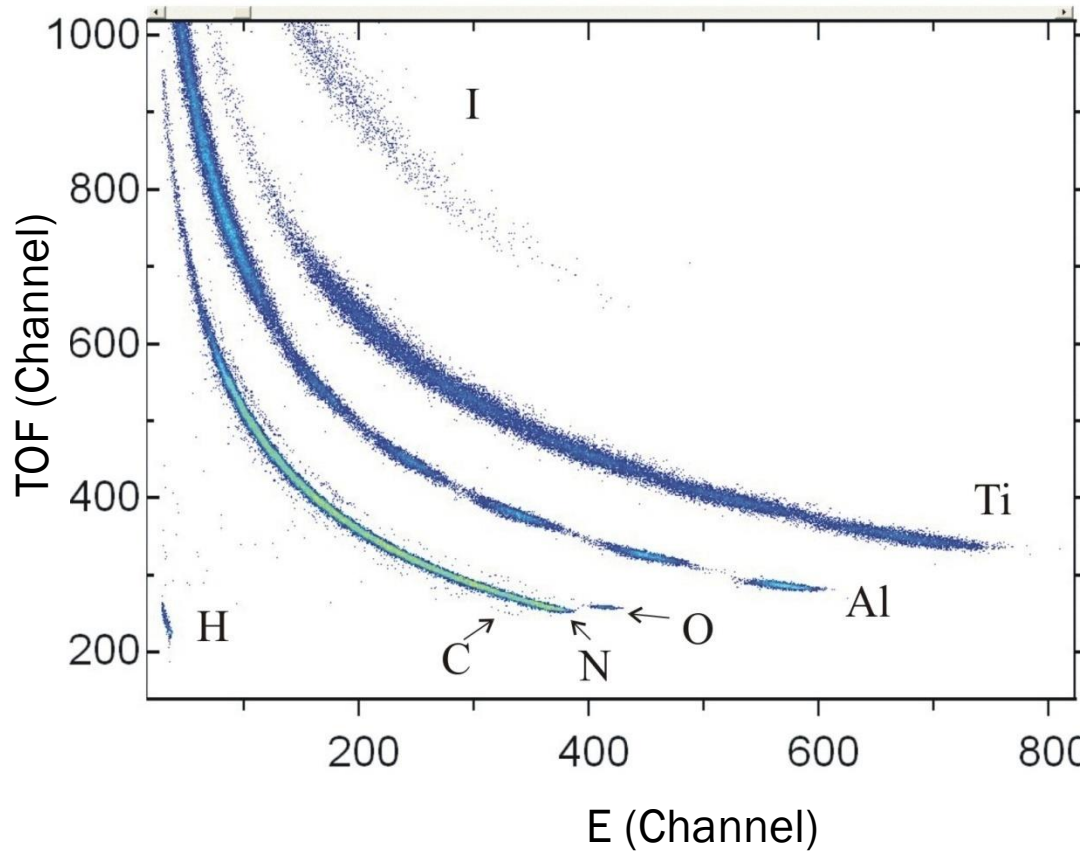
Beam: 20 MeV $^{81}\text{Br}^{5+}$



TOF ERDA APPLICATION – Multilayer samples

Beam: 25 MeV ^{127}I , $\theta_{\text{in}} = 5^\circ$, $\theta_{\text{scatt.}} = 37.5^\circ$

Target: 5x AlN/TiN 20 nm layers

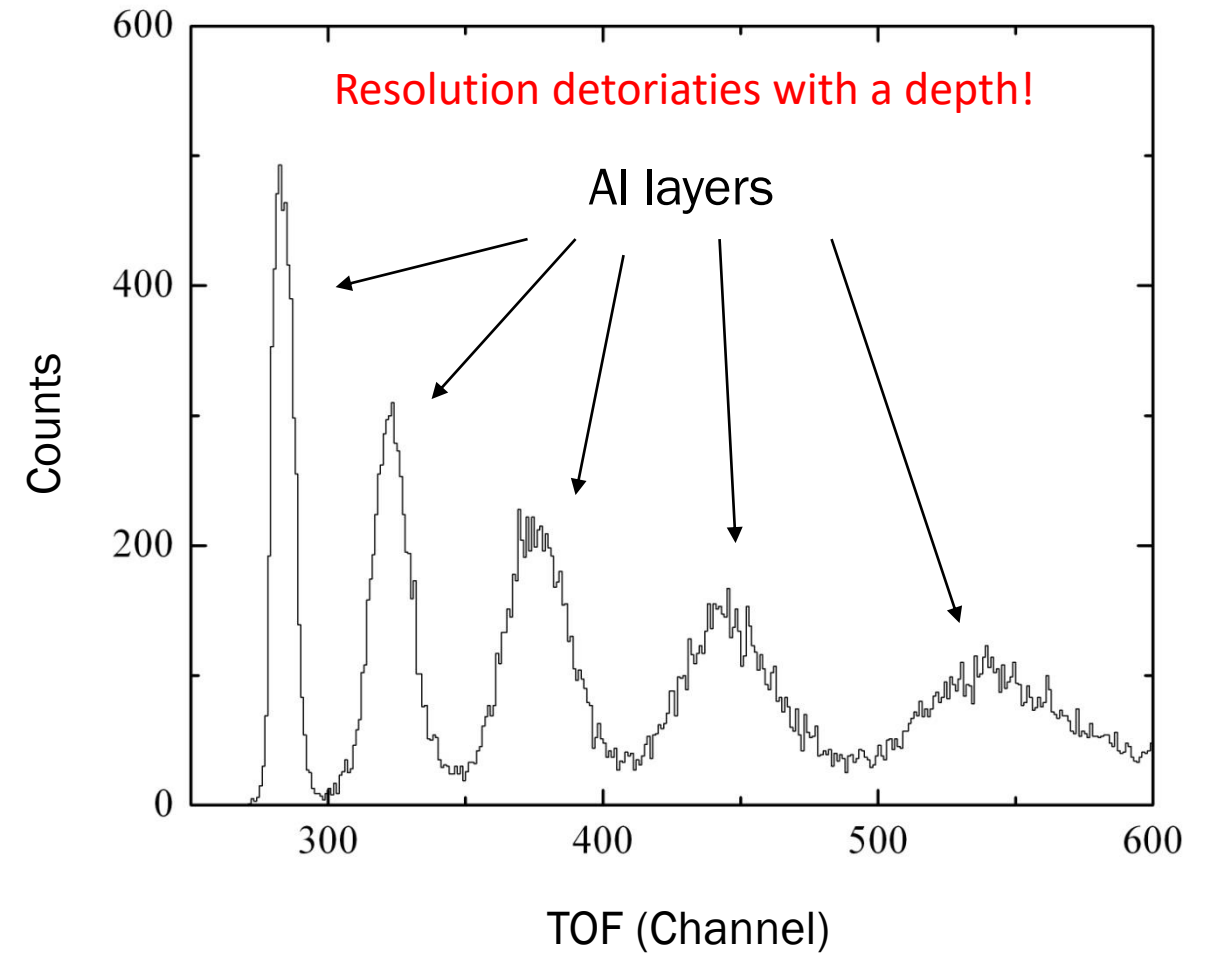


Time spectra of the Al events

Result of the analysis:

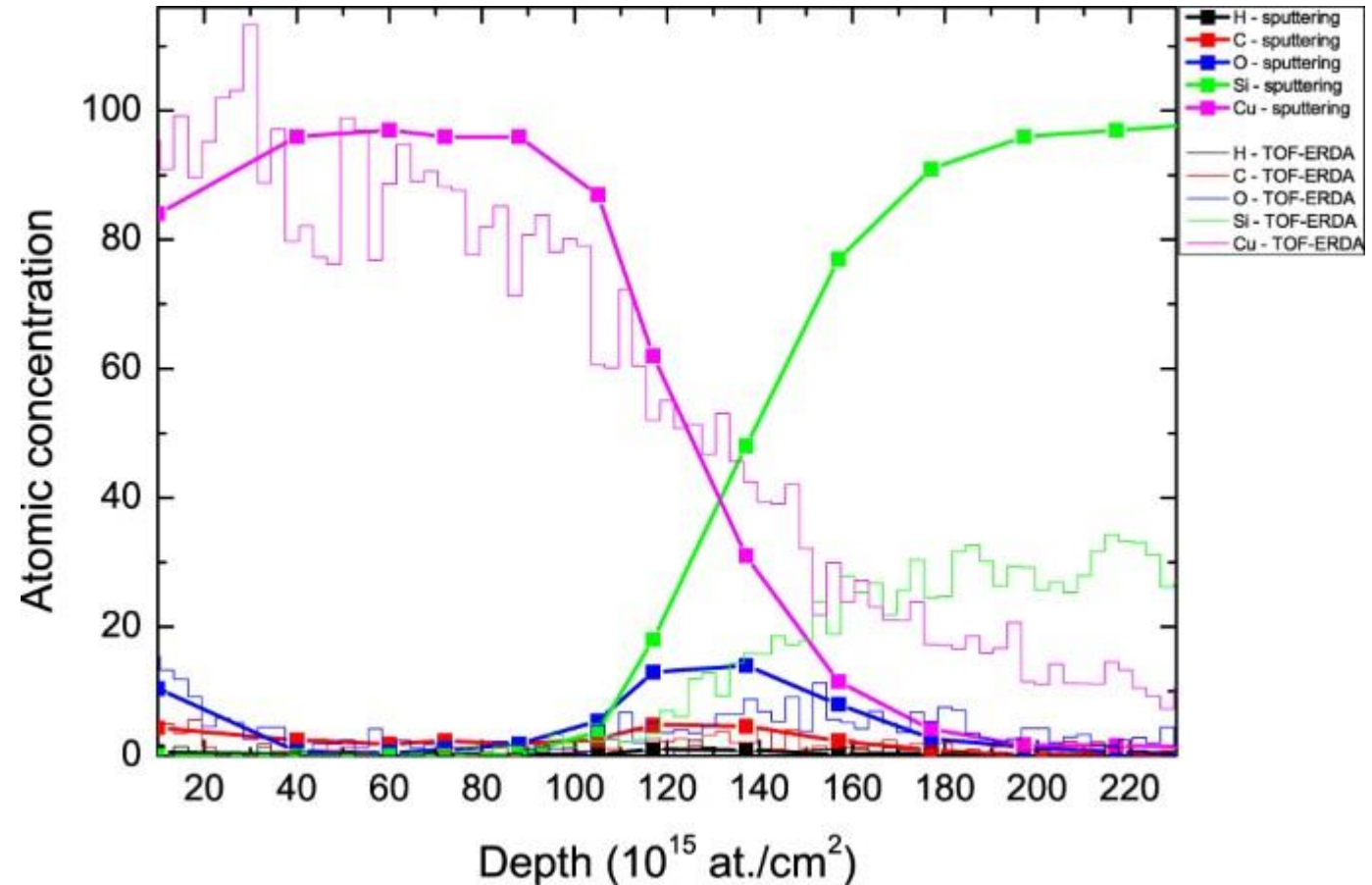
Al:N=1:1, $d = 24$ nm

Ti:N=1:1, $d = 40$ nm



TOF ERDA + Ar SPUTTERING

- TOF-ERDA used to measure the surface elemental composition, Ar sputtering to extract the depth information
- **best achievable (surface) resolution of 2 nm for the entire layer**



TOF ERDA promoted by argon sputtering (lines + symbols) and TOF-ERDA (lines) depth profile for a 15-nm-thick Cu layer evaporated onto the Si substrate.

Siketić, Z., Bogdanović Radović, I., Sudić, I. *et al.* Surface analysis and depth profiling using time-of-flight elastic recoil detection analysis with argon sputtering. *Sci Rep* **8**, 10392 (2018).

MeV TOF-SIMS

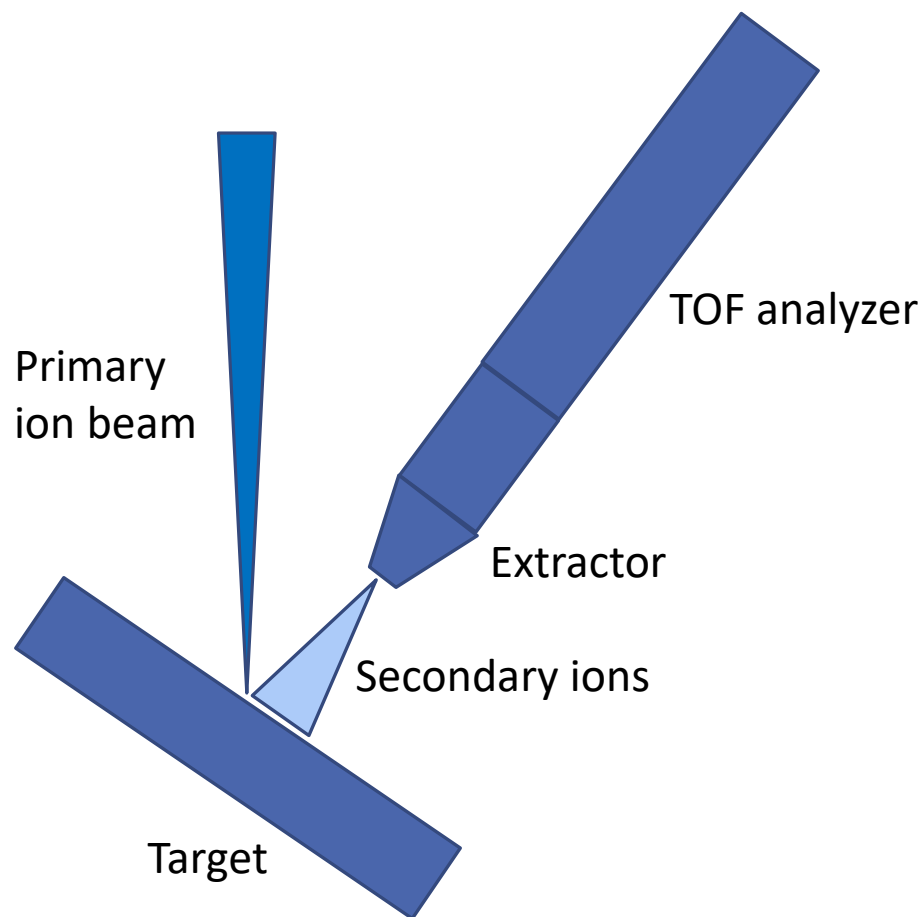
Time-of-Flight Secondary Ion Mass Spectrometry

MeV SIMS

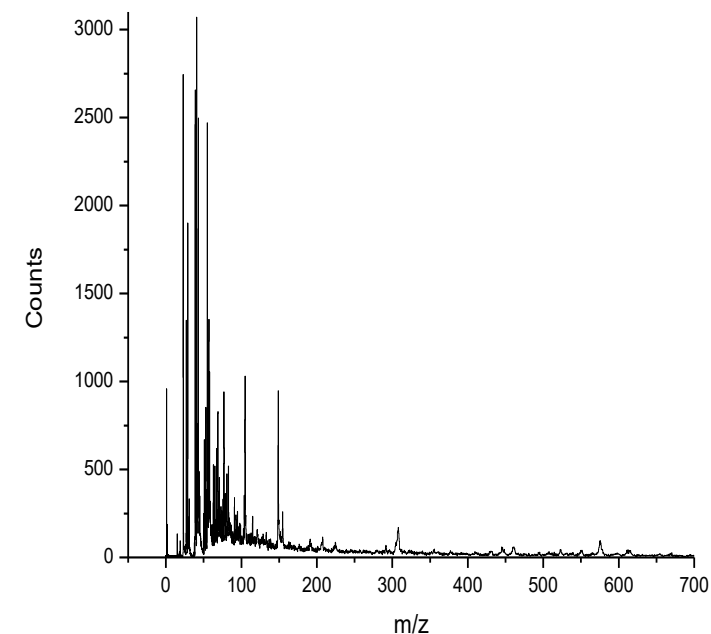
= mass spectrometry technique used for identification of atomic and molecular species by measuring time-of-flight of the secondary ions sputtered from the sample surface

$$E = qV = \frac{m}{2}v^2 = \frac{m}{2}\left(\frac{L}{TOF}\right)^2 \rightarrow \boxed{m/q = 2V\left(\frac{TOF}{L}\right)^2}$$

(E_0 few eV)

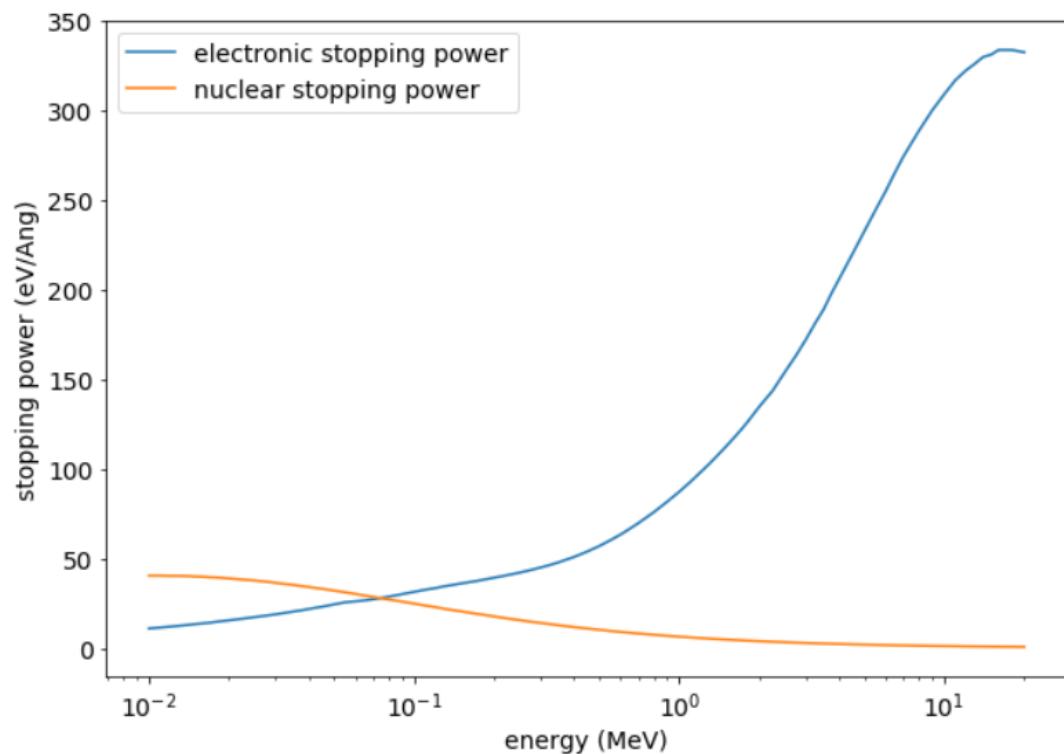


TOF spectrum \longleftrightarrow Mass spectrum

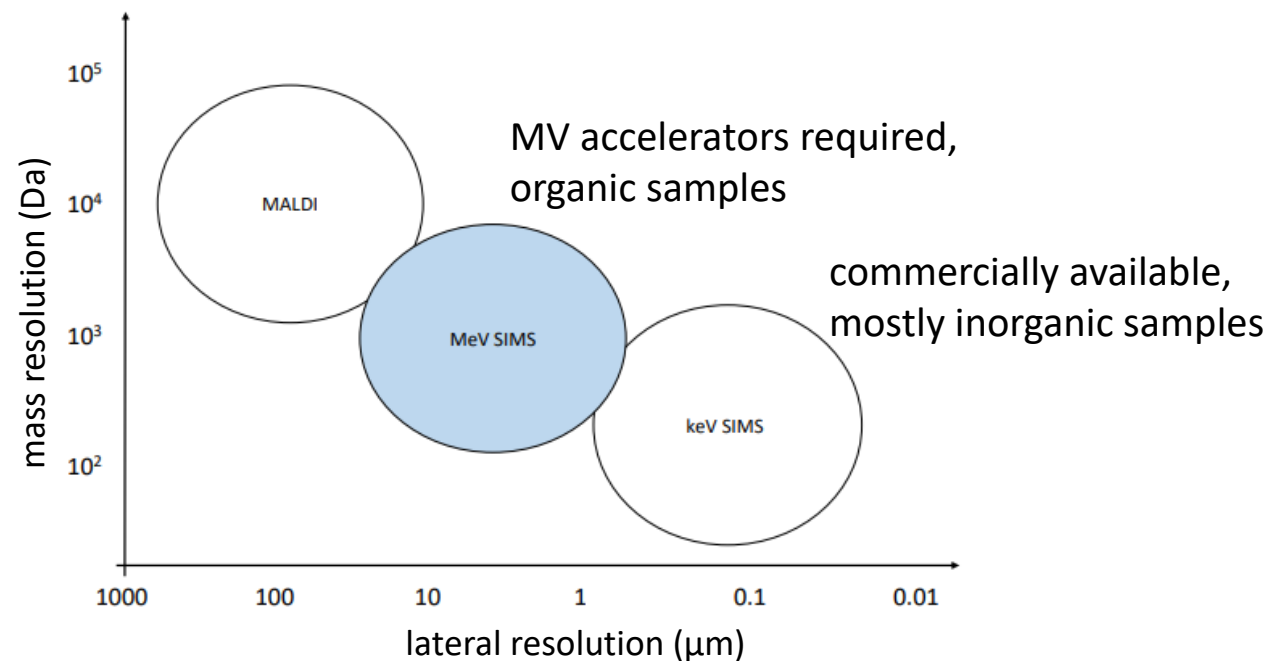


Scanning over the sample \longrightarrow Imaging (2D spatial molecular distribution)

- **Higher SI yield** for heavier molecules, and **less fragmentation**, than for keV counterpart



Silicon beam on a leucine target:
electronic stopping dominates for MeV energies



TOF mass spectrometry techniques comparison

MeV SIMS APPLICATIONS @ RBI

Since 2014 we published 16 papers in high IF journals on application of MeV SIMS analysis:

- Biology (identification of lipids and fatty acids in various tissues and single cells, 2 papers published)
- Cultural heritage (identification of pigments and binders of modern paint materials, 3 papers published)
- Forensics (study of deposition order of crossing lines of different writing tools, 3 papers published)
- Simultaneously analysis of organic and inorganic materials (2 papers published)
- Development of MeV SIMS and measurements of fundamental parameters (6 papers published)

scientific reports

OPEN

Depth profiling of Cr-ITO dual-layer sample with secondary ion mass spectrometry using MeV ions in the low energy region

Marko Barac^{1,2,3}, Marko Brajković¹, Zdravko Siketić¹, Jernej Ekar^{2,3}, Iva Bogdanović Radović¹, Iva Šrut Rakić⁴ & Janez Kovač³

Identification of Synthetic Organic Pigments (SOPs) Used in Modern Artist's Paints with Secondary Ion Mass Spectrometry with MeV Ions

Matea Krmpotić,* Dubravka Jembrih-Simbürger, Zdravko Siketić, Nikola Marković, Marta Anghelone, Tonči Tadić, Dora Plavčić, Mason Malloy, and Iva Bogdanović Radović



Diabetes Research and Clinical Practice
Volume 159, January 2020, 107986



Study of the diacylglycerol composition in the liver and serum of mice with prediabetes and diabetes using MeV TOF-SIMS

Marijana Popović Hadžija^{a,*,‡}, Zdravko Siketić^b, Miro Hadžija^a, Marko Barac^b, Iva Bogdanović Radović^b

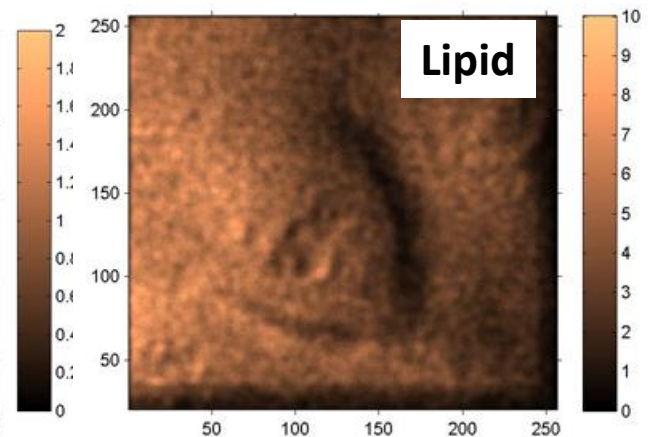
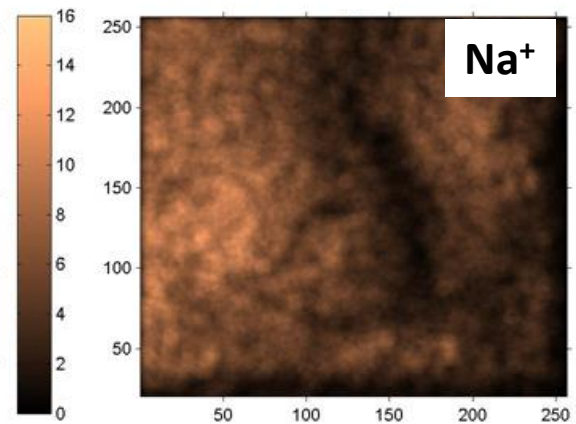
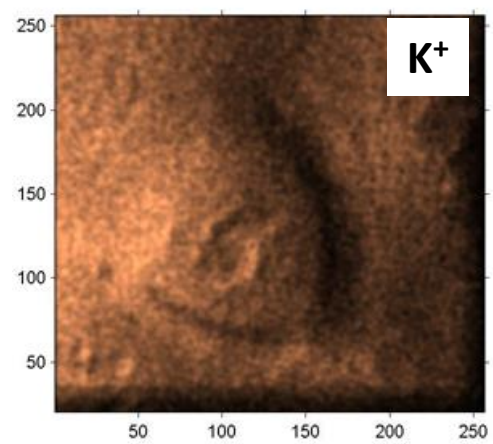
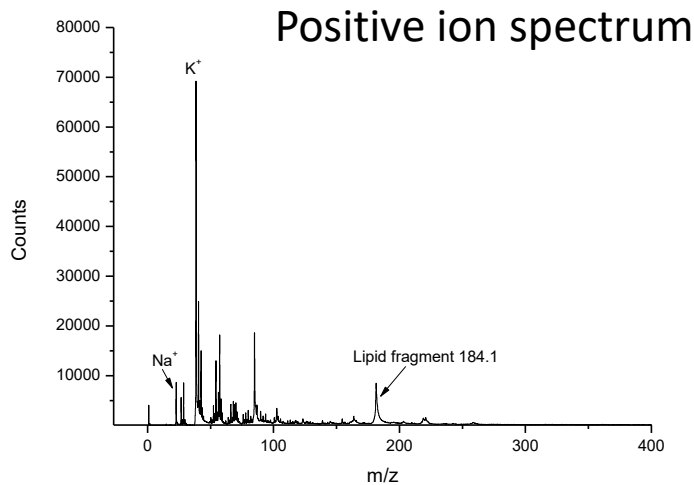
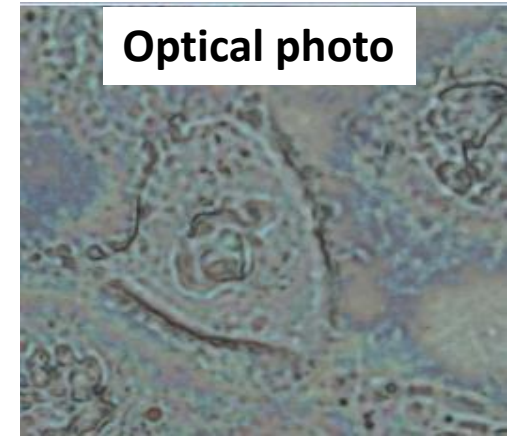
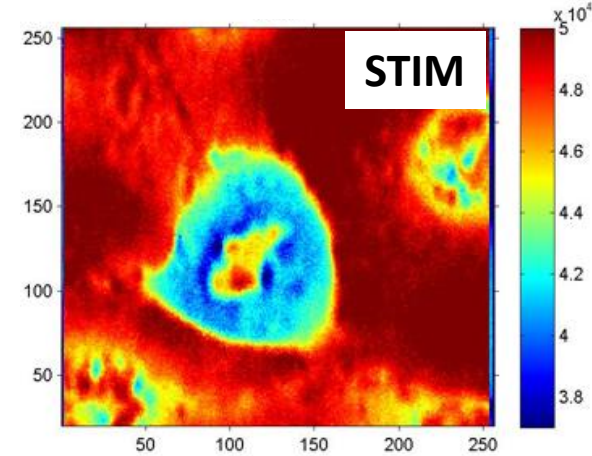
MeV SIMS: APPLICATIONS

Example #1: Molecular imaging of single CaCo-2 cancer cell

Siketić, Z., Bogdanović Radović, I., Jakšić, M., Popović Hadžija, M., & Hadžija, M. (2015) Applied Physics Letters, 107(9), 093702.

Beam: 9 MeV O^{4+}

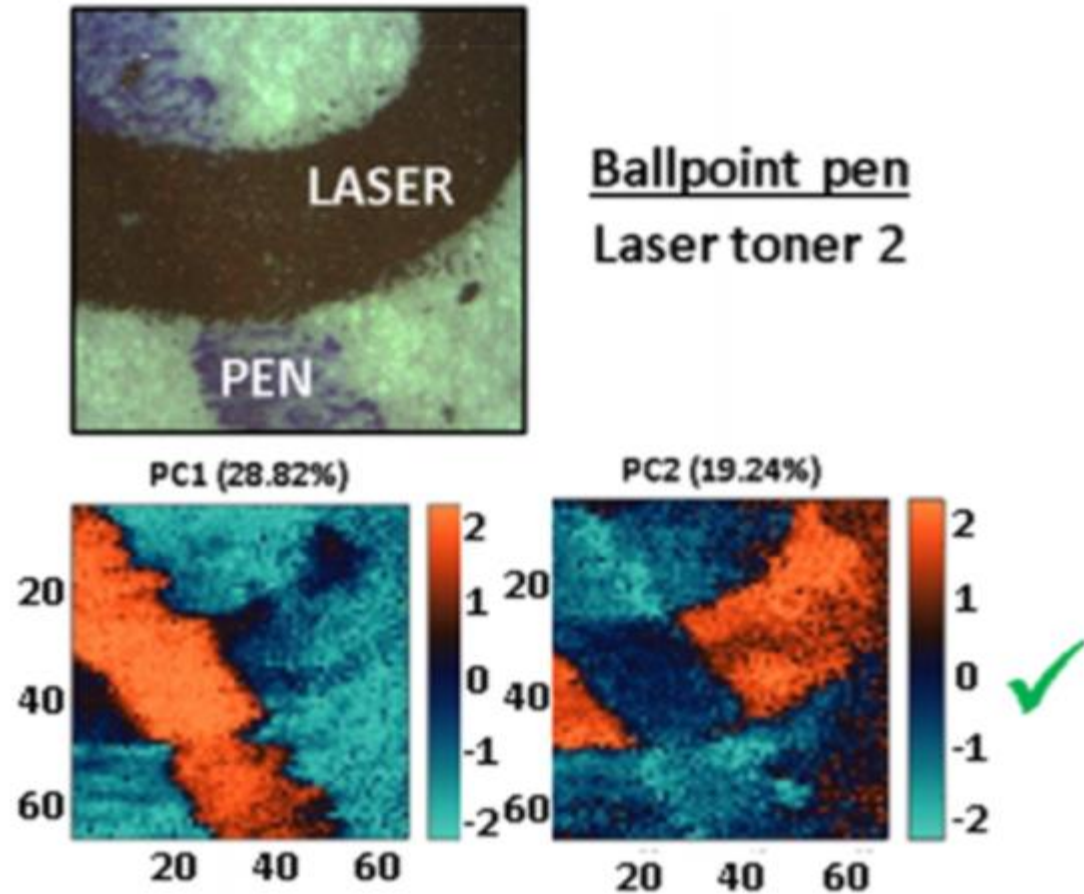
Scan size: $85 \times 85 \mu m^2$ (≈ 300 nm/pixel)



MeV SIMS: APPLICATIONS

Example #2: **Forensics: determination of deposition order of inks/toners**

Moore, K. L., Barac, M., Brajković, M., Bailey, M. J., Siketić, Z., &
Bogdanović Radović, I. (2019) Analytical chemistry, 91(20), 12997-13005.



Ink crossing imaging + PCA analysis

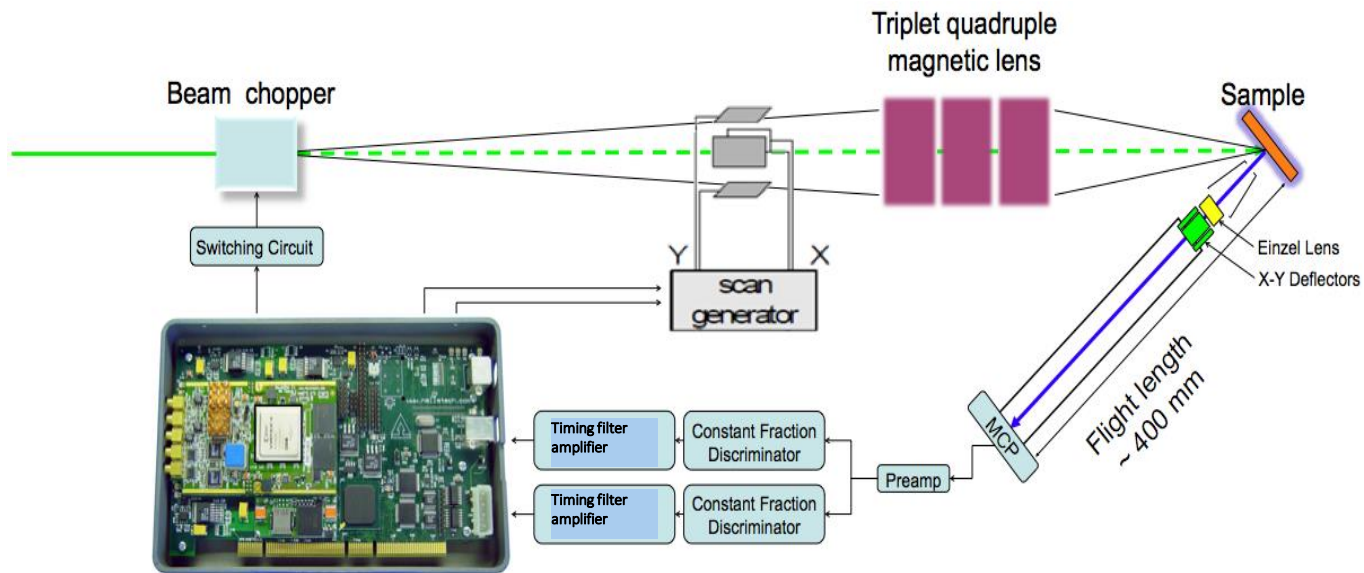
MeV SIMS: OLD SETUP

TOF START: Primary beam pulsing

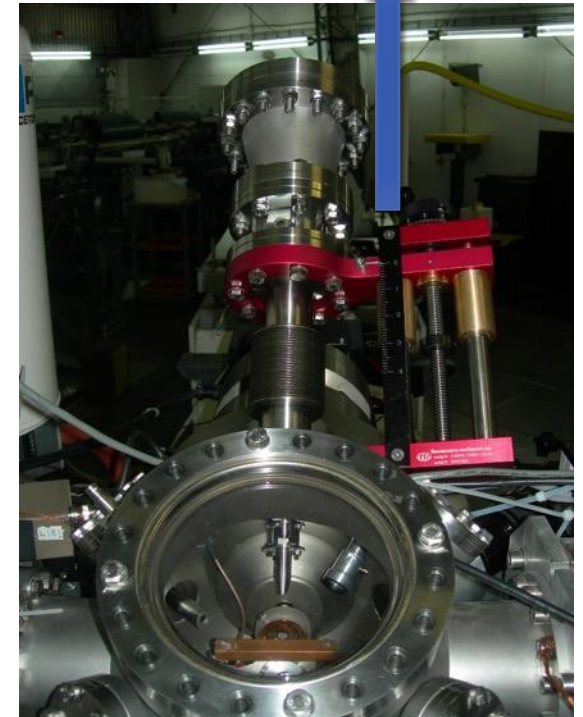
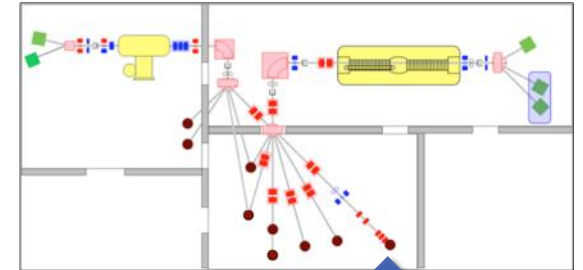
TOF STOP: MCP detector

FOCUSING: magnetic lenses

IMAGING: Primary beam scanning over the sample



Cannot use ions heavier than Silicon!
upper limit: $m \cdot E / q^2 < 14 \text{ MeV amu}$



ALTERNATIVE: COLLIMATED BEAM

- cheap alternative for magnetic focusing for small current (fA) application
- collimation independent on ion mass and energy = heavy, high energy ion can be used
- in principle, in-air extraction possible



COLLIMATED BEAM:

TOF START: ~~Primary beam pulsing~~ ?

TOF STOP: MCP detector (upgraded with 10 kV postacceleration)

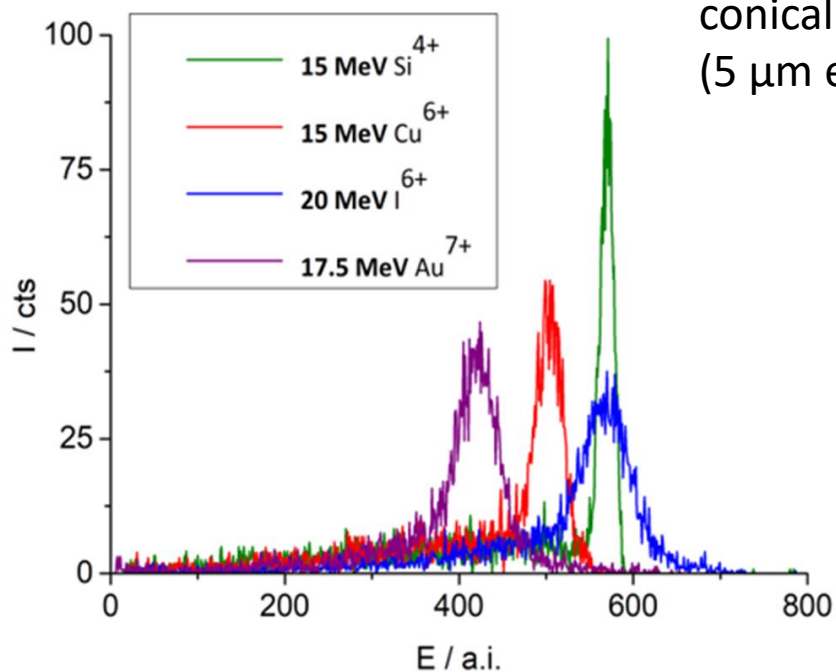
FOCUSING: ~~COLLIMATION~~ **COLLIMATION with micro-capillary/micro-aperture**

IMAGING: sample placed on piezo-stage in front of fixed collimator

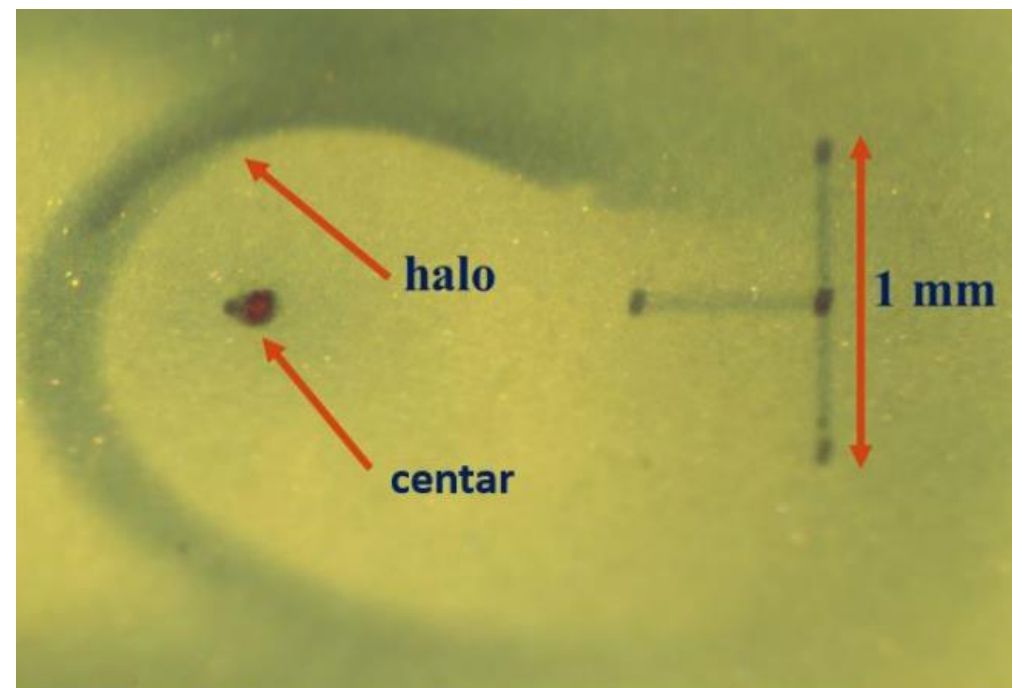
MICROCAPILLARY: TRANSMISSION



conically-shaped glass capillary
(5 µm exit diameter)



energy spectra of
transmitted beams

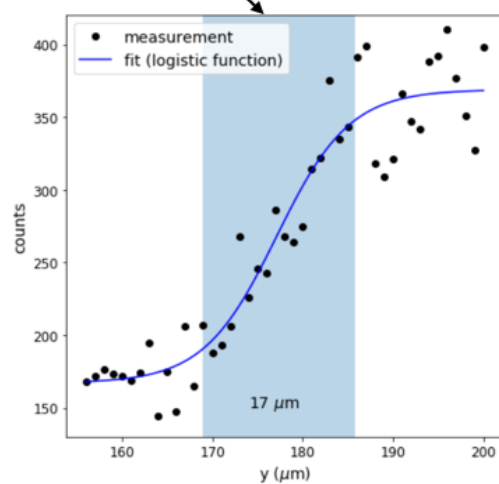
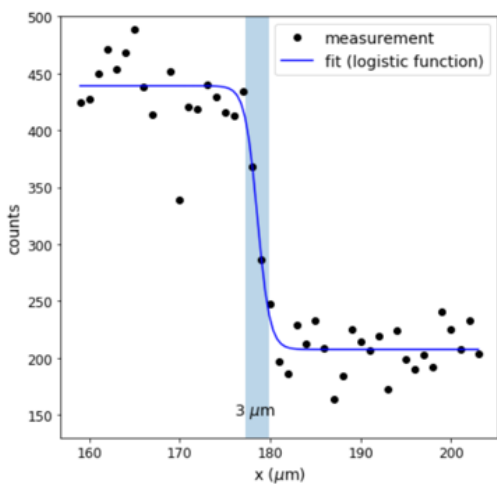
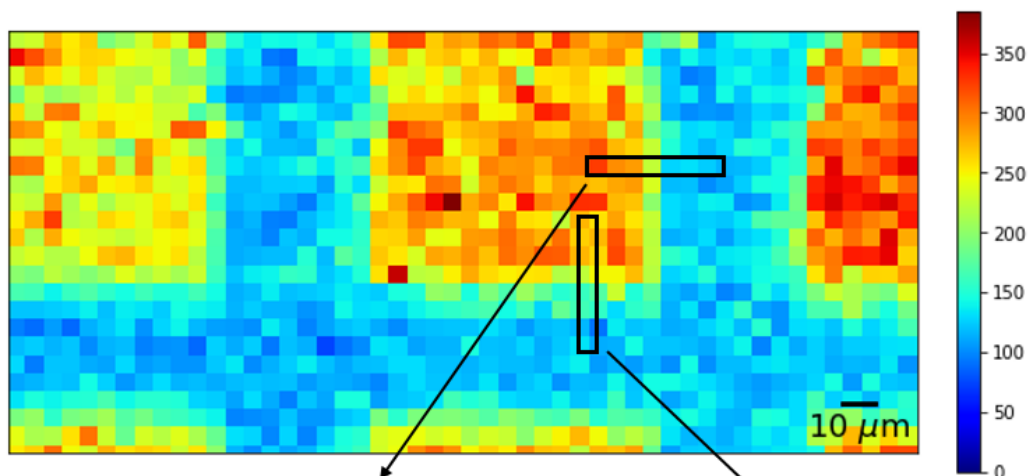


spatial distribution of transmitted beam

M. Brajković, M. Barac, D. Cosic, I. Bogdanović Radović,
Z. Siketić, Development of MeV TOF-SIMS capillary
microprobe at the Ruđer Bošković Institute in Zagreb,
Nucl. Instr. and Meth. B 461 (2019) 237-242.

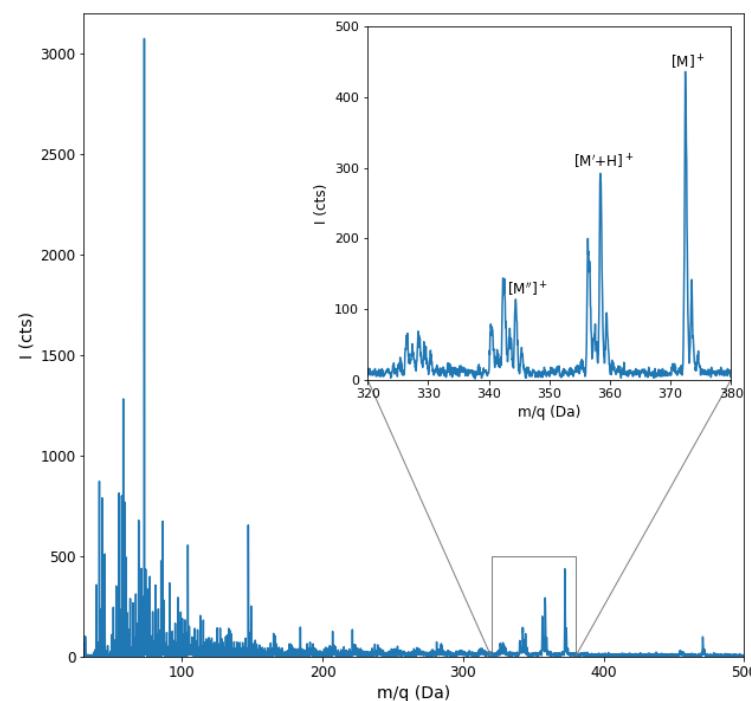
MICROCAPILLARY: IMAGING

lateral resolution: leucine-evaporated copper mesh

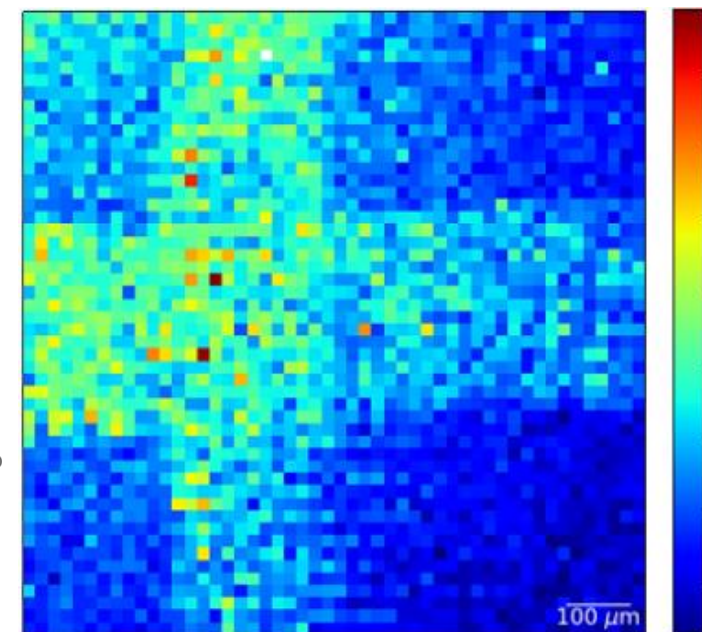
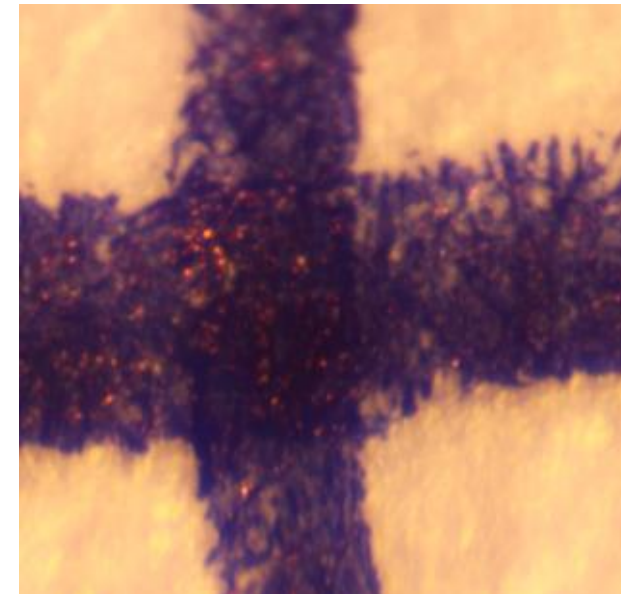


M. Brajković, I. Bogdanović Radović, M. Barac, D. D. Cosic, Z. Siketić, Imaging of Organic Samples with Megaelectron Volt Time-of-Flight Secondary Ion Mass Spectrometry Capillary Microprobe, J. Am. Soc. Mass Spectrom. 2021, 32, 10, 2567–2572.

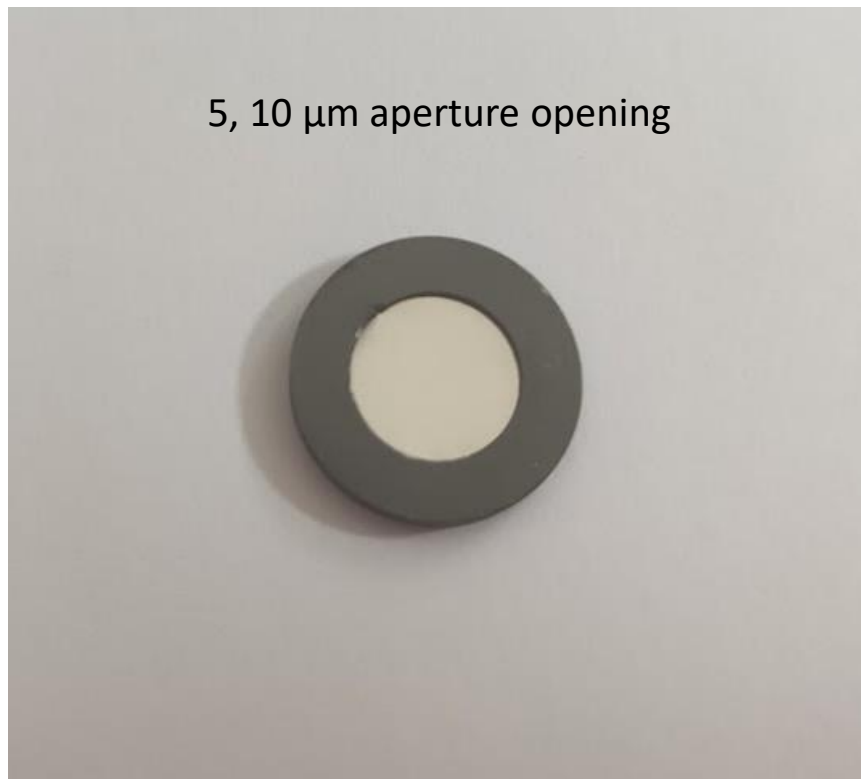
Imaging: ink crossing on a paper



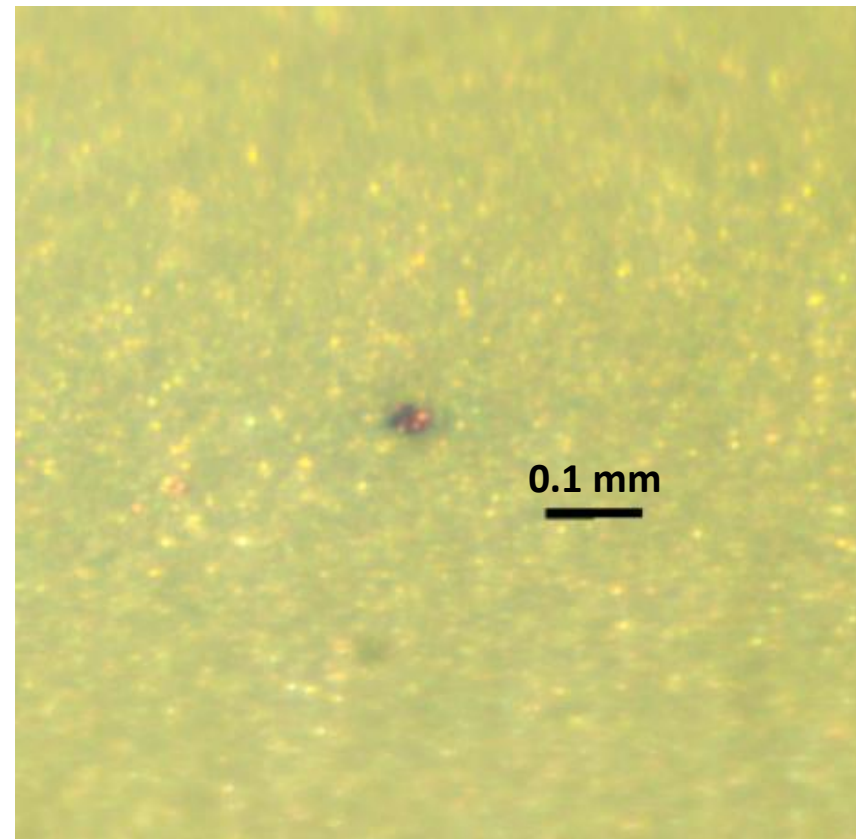
CONS: halo and low contrast



5 μm APERTURE

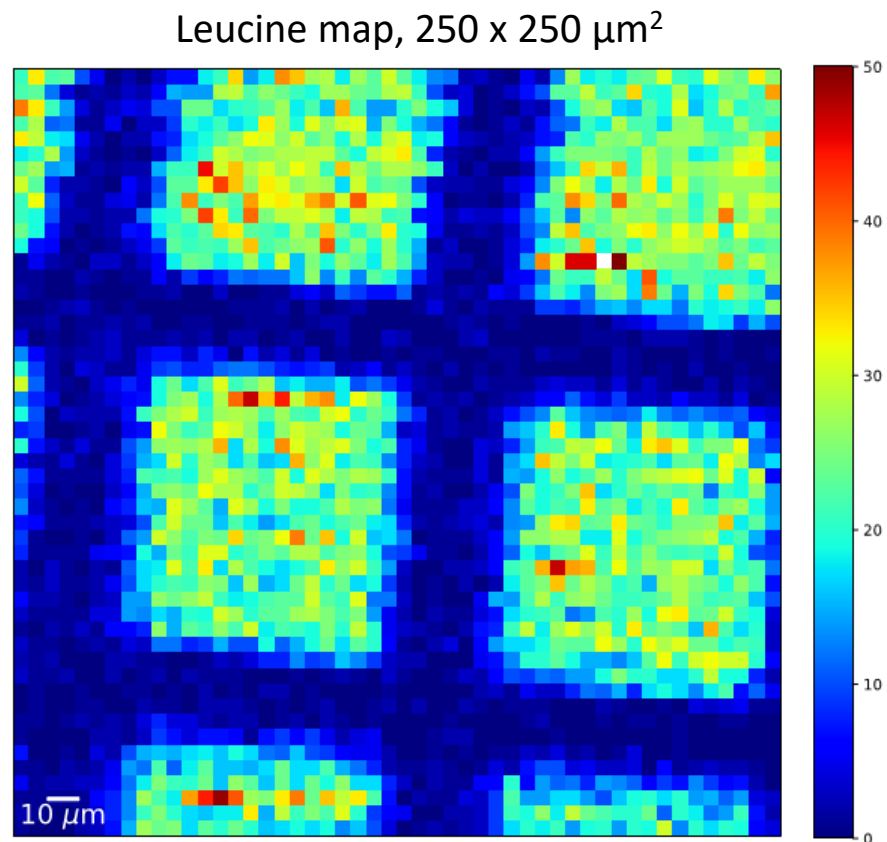


steel, thickness 12.7 μm , aluminum frame



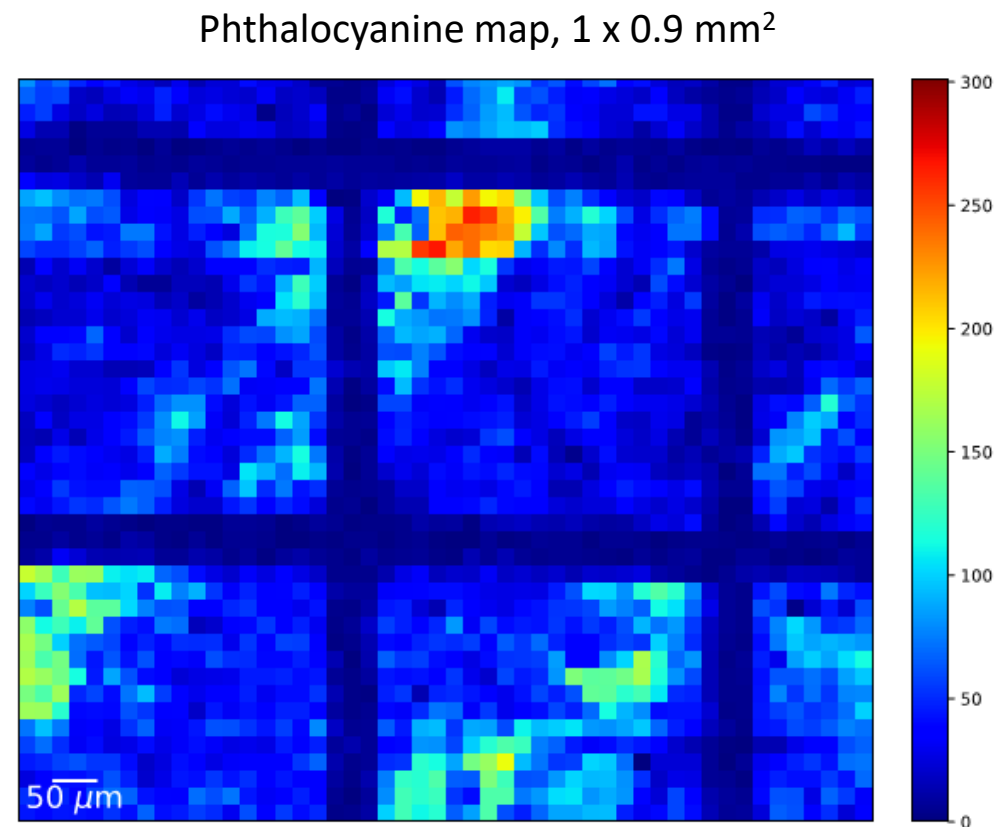
beam through the aperture on Gafchromic EBT3 film

IMAGING #1: MESH



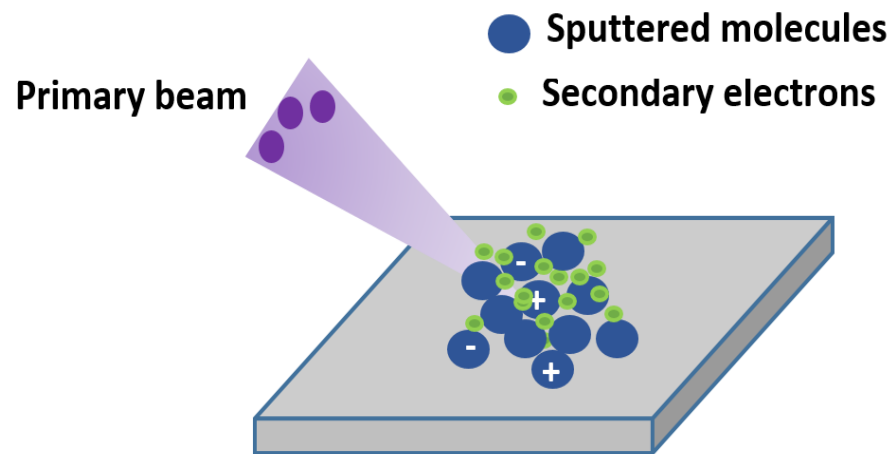
transmission: mesh with $127 \mu\text{m}$ pitch
lateral resolution $\approx 10 \mu\text{m}$ (for $5 \mu\text{m}$ aperture)

MUCH BETTER CONTRAST COMPARED TO THE CAPILLARY!



electron start: mesh with $440 \mu\text{m}$ pitch

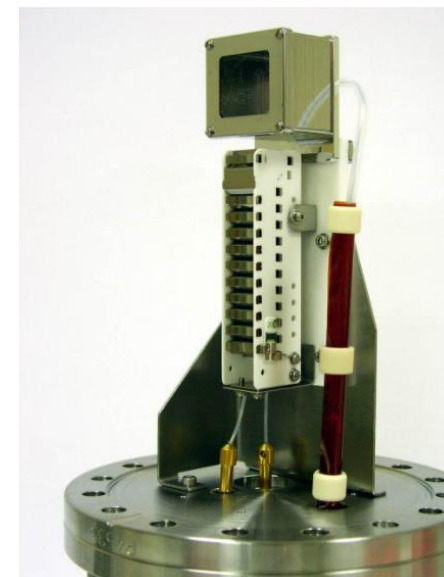
? TWO TOF **START** TRIGGER OPTIONS



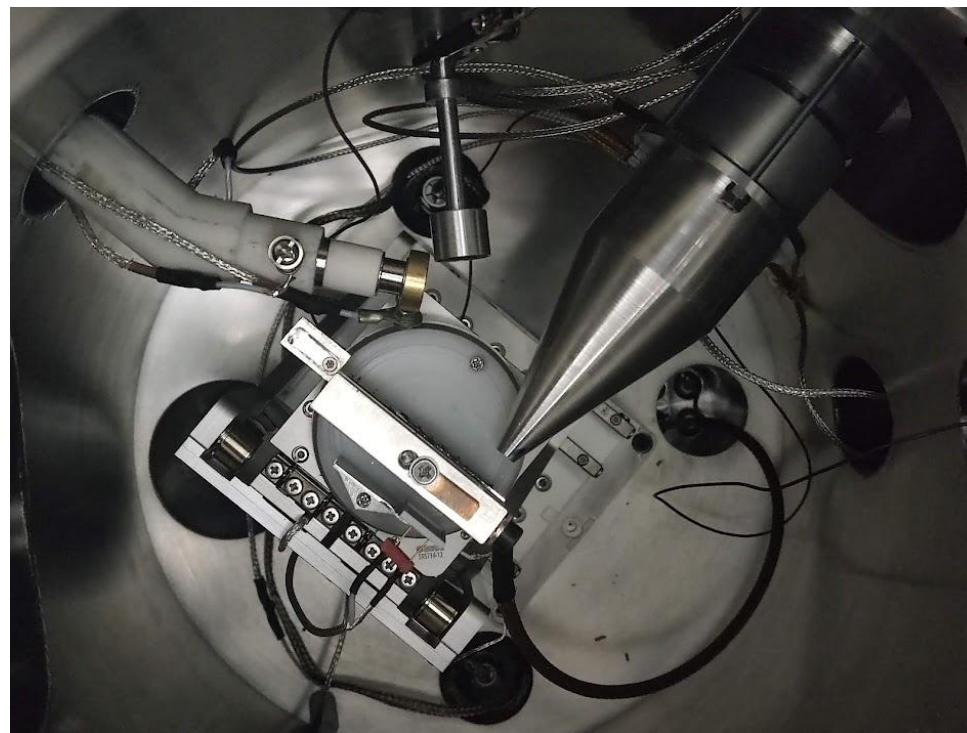
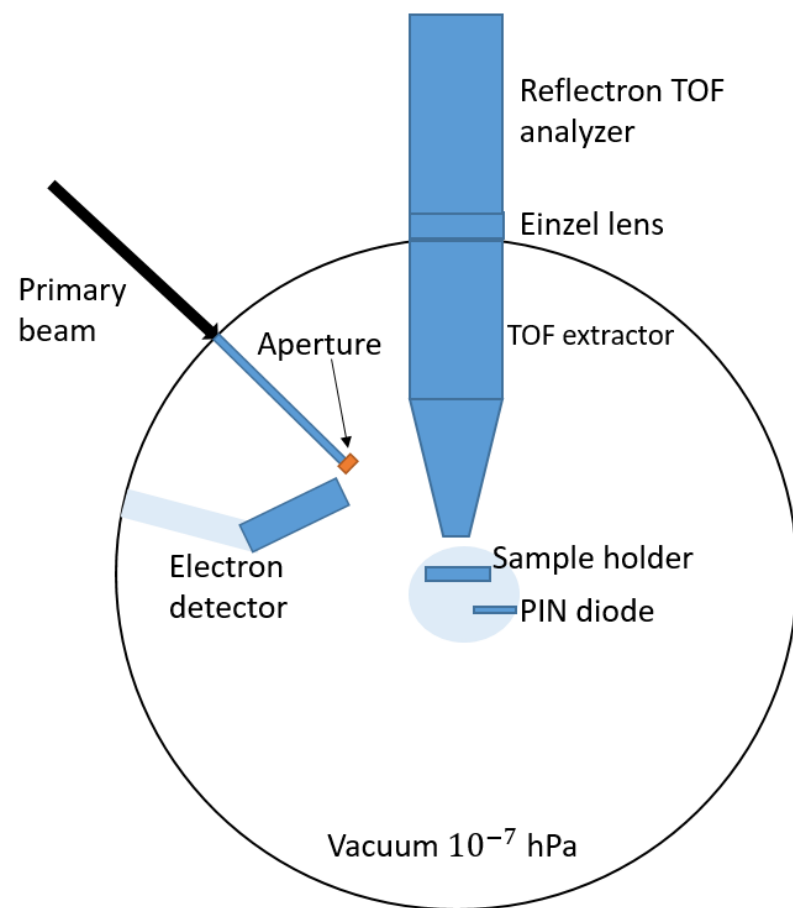
- Primary ion detection (by a PIN diode)
simple setup, good mass resolution
thin targets only, radiation damage
- Detection of secondary electrons
thick targets, radiation hard
complicated setup

STOP signal

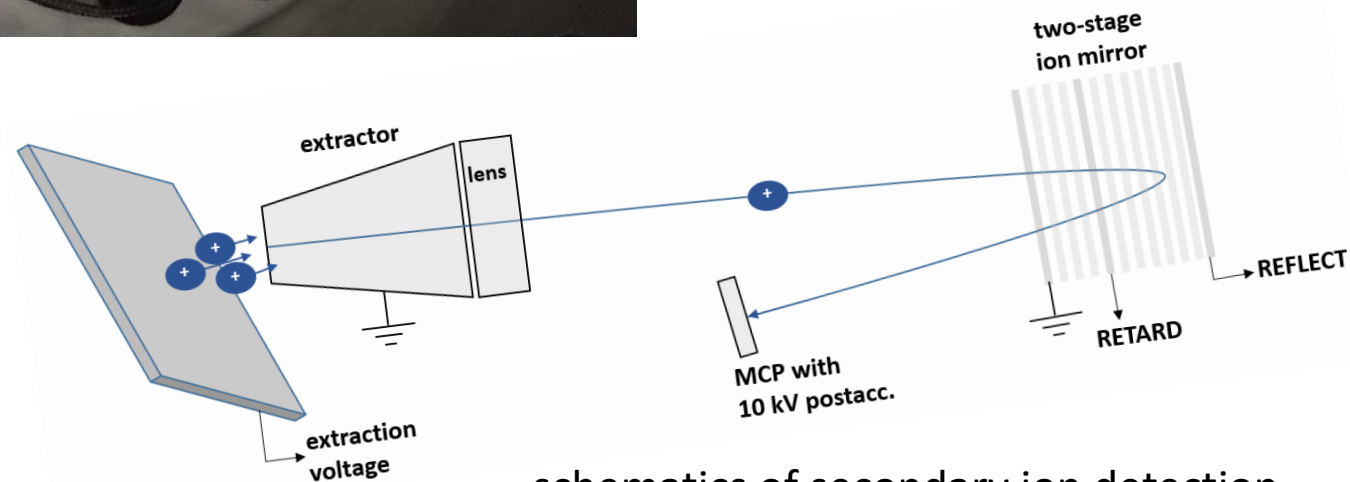
Kore detector with 10 kV postacceleration



THE SETUP



thin carbon foil (5 nm thickness) over the aperture = **the production of secondary electrons sample-independent** (for example, 7 kHz from a silicon plate but only 1 kHz from a paper)

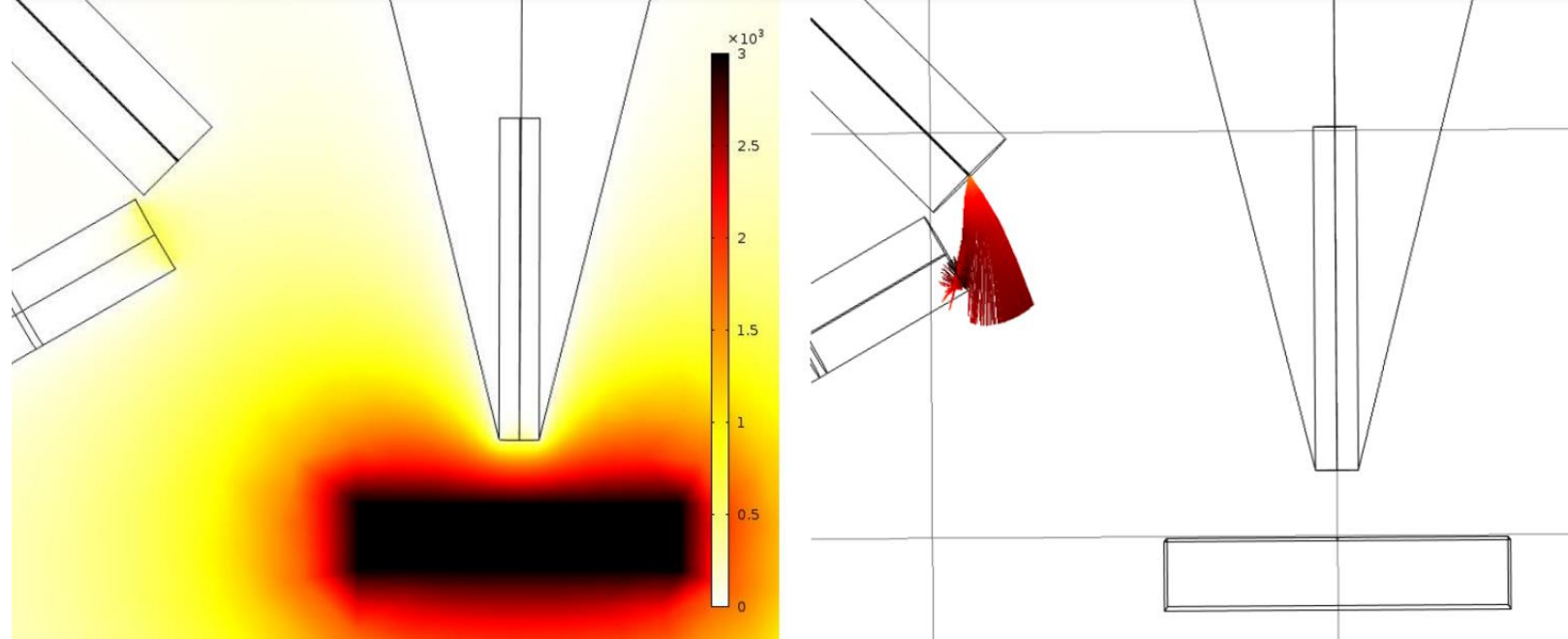


schematics of secondary ion detection

THICK TARGET SETUP: DETECTION OF ELECTRONS

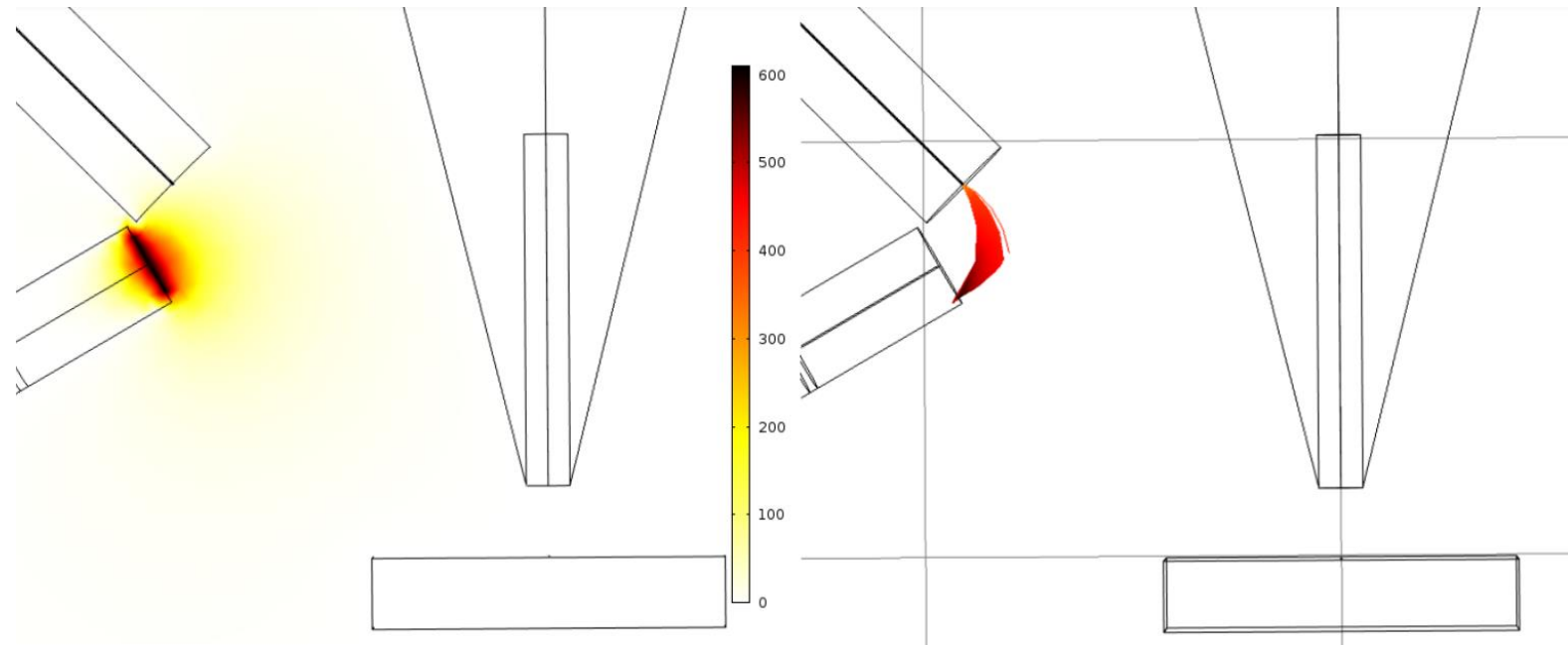
COMSOL simulations

electric potential and electron
trajectories with the target at the
extraction potential



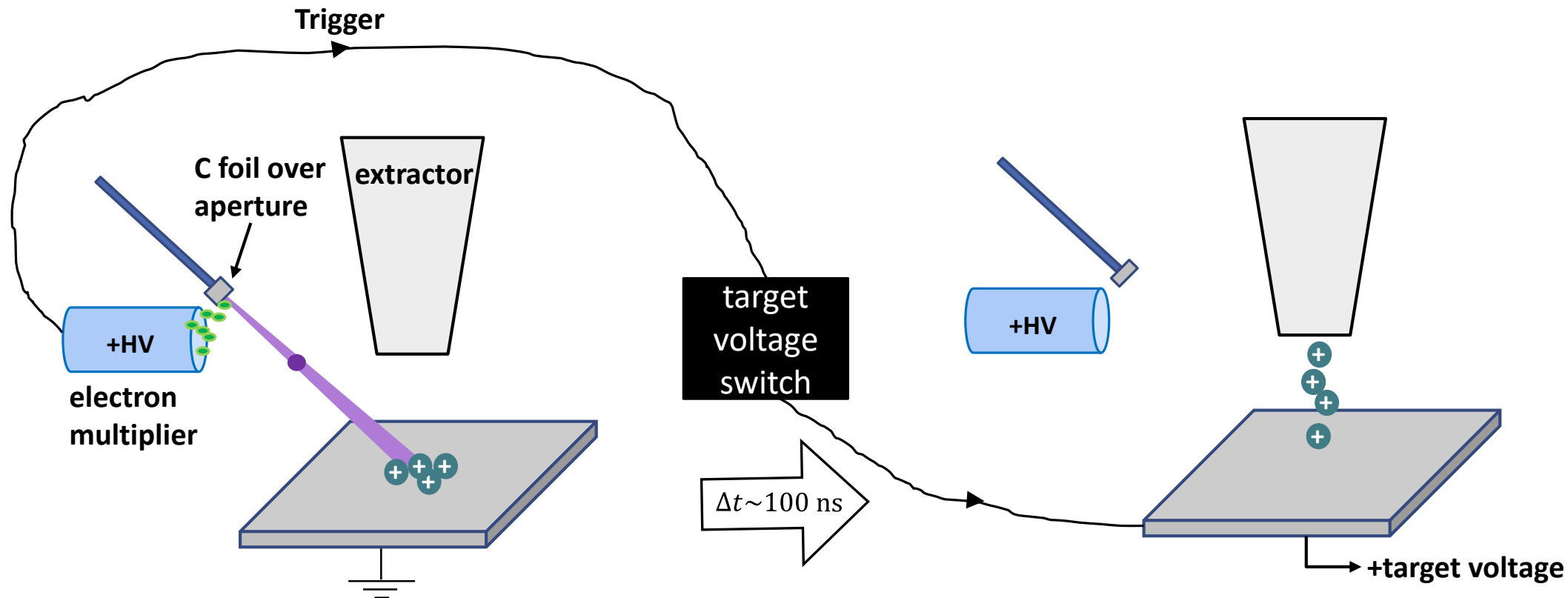
TARGET CANNOT BE HELD AT CONSTANT (EXTRACTION) VOLTAGE!

electric potential distribution
and electron detection with the
target at zero potential



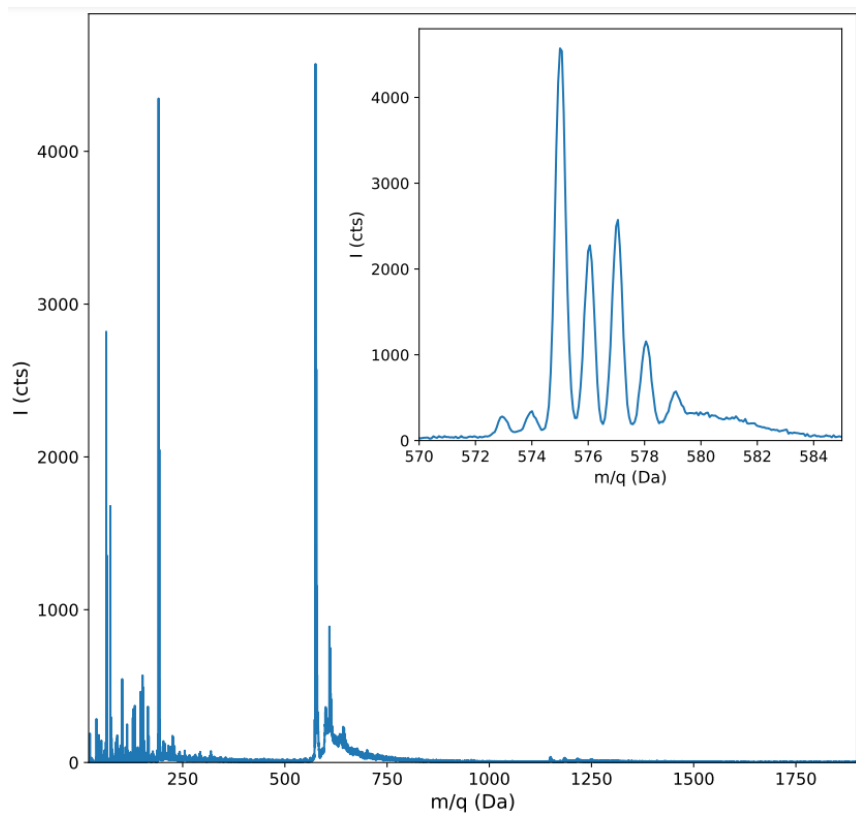
SCHEMATIC OVERVIEW OF THE THICK-TARGET SETUP: DETECTION OF SECONDARY ELECTRONS

M. Brajković, I. Bogdanović Radović, M. Barac, D. D. Cosic, Z. Siketić, Imaging of Organic Samples with Megaelectron Volt Time-of-Flight Secondary Ion Mass Spectrometry Capillary Microprobe, J. Am. Soc. Mass Spectrom. 2021, 32, 10, 2567–2572.



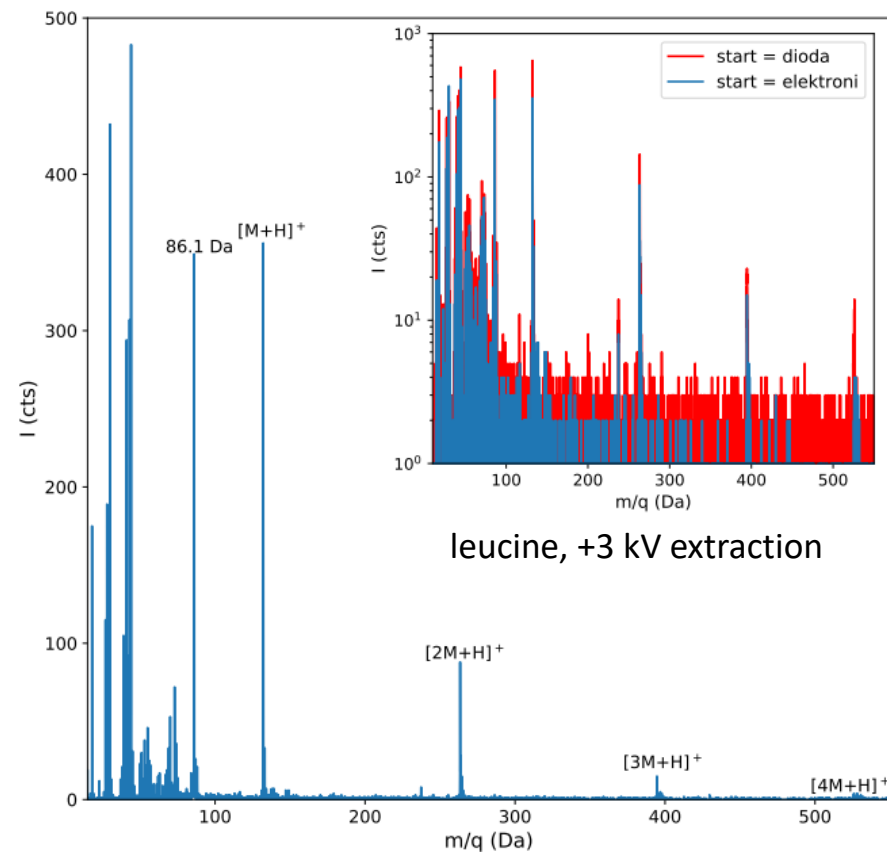
- target voltage applied only for 2 μs
- delayed extraction
- extraction blocked for the remaining part of the acquisition window (98 μs)

MASS SPECTRUM: TWO MODES



Phthalocyanine blue ($m = 576.1$ Da) mass spectrum with 10 kV postacc. detector

Comparison of two modes of operation



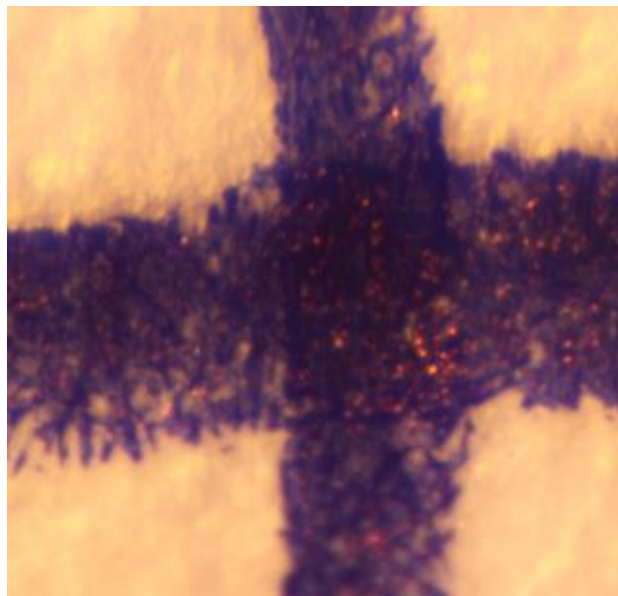
leucine, +3 kV extraction

Mass resolution (for $m = 576.1$ Da):

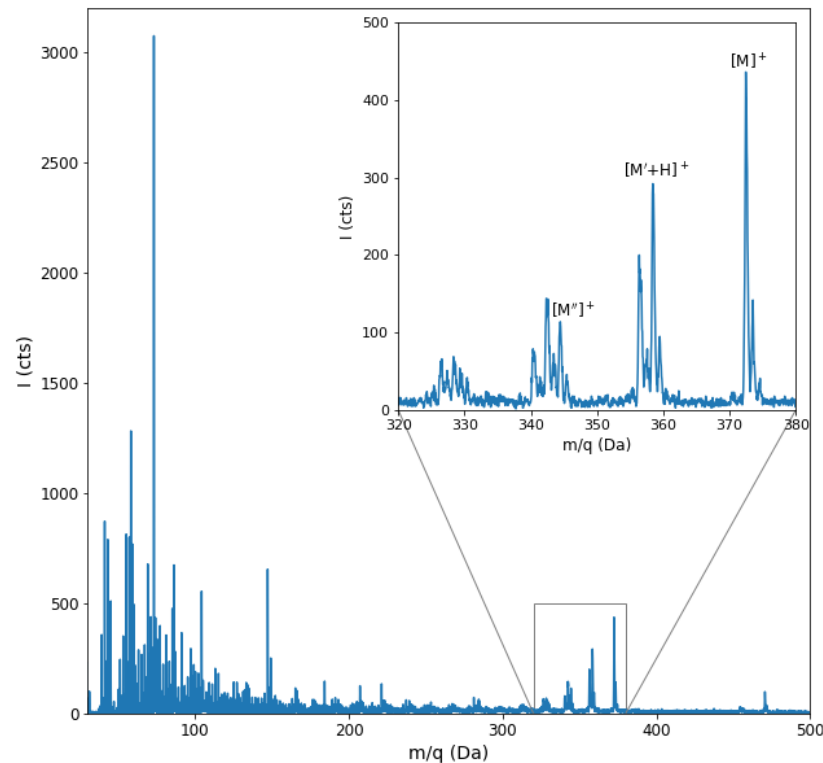
- 2500 in the transmission mode
- 1400 in the electron start mode

but **S/N ration 2 – 5 times better in electron start mode**
(random coincidences minimized)

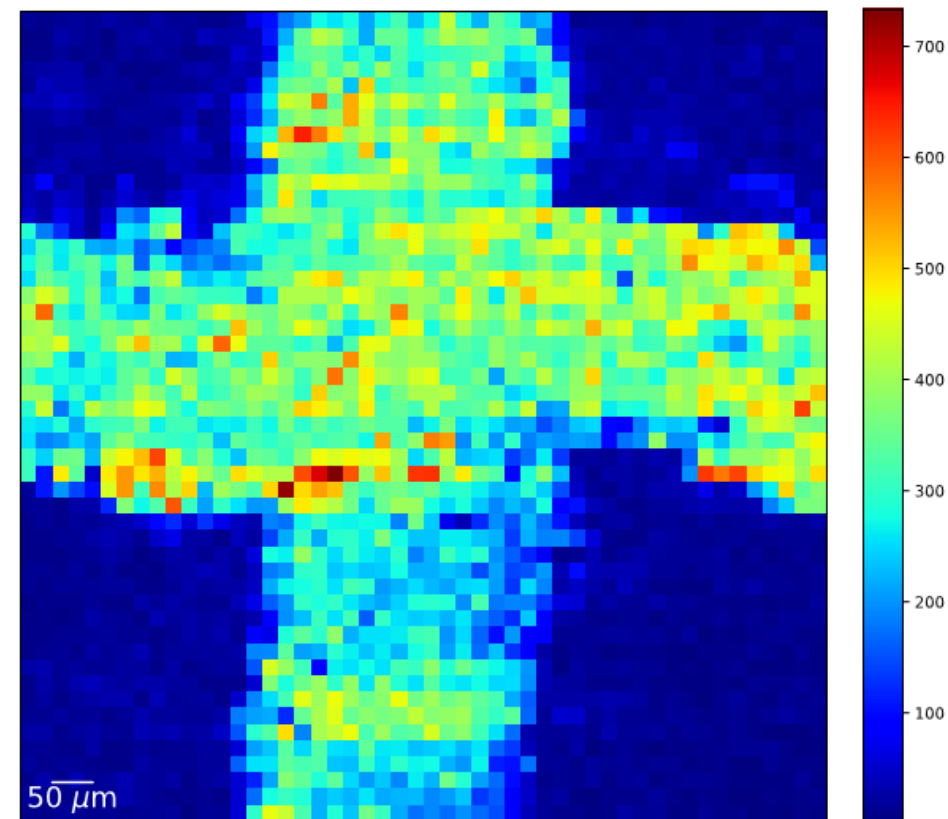
IMAGING #2: INK CROSSING ON A PAPER



optical photo of ink
crossing on a paper

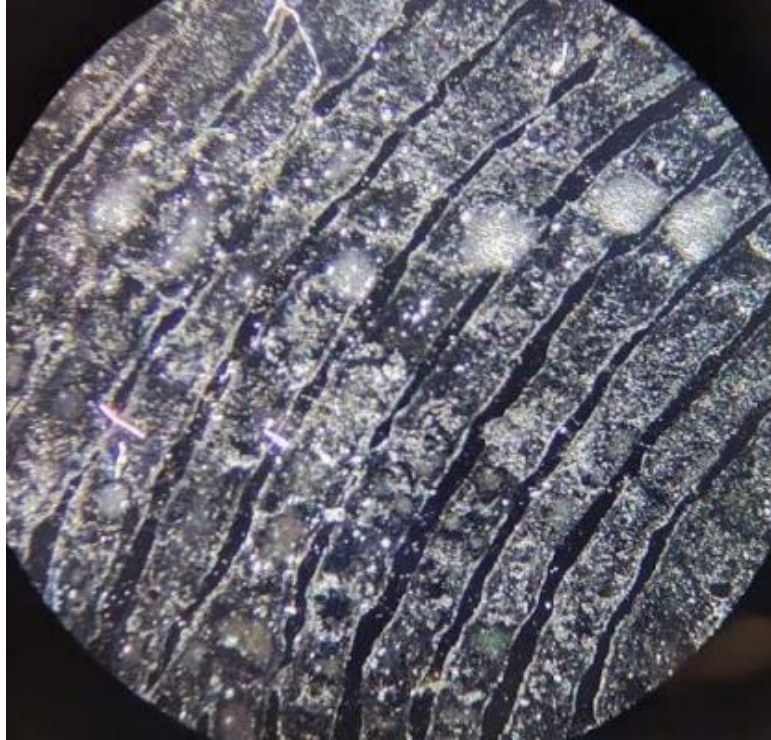


mass spectrum from
the ink crossing area

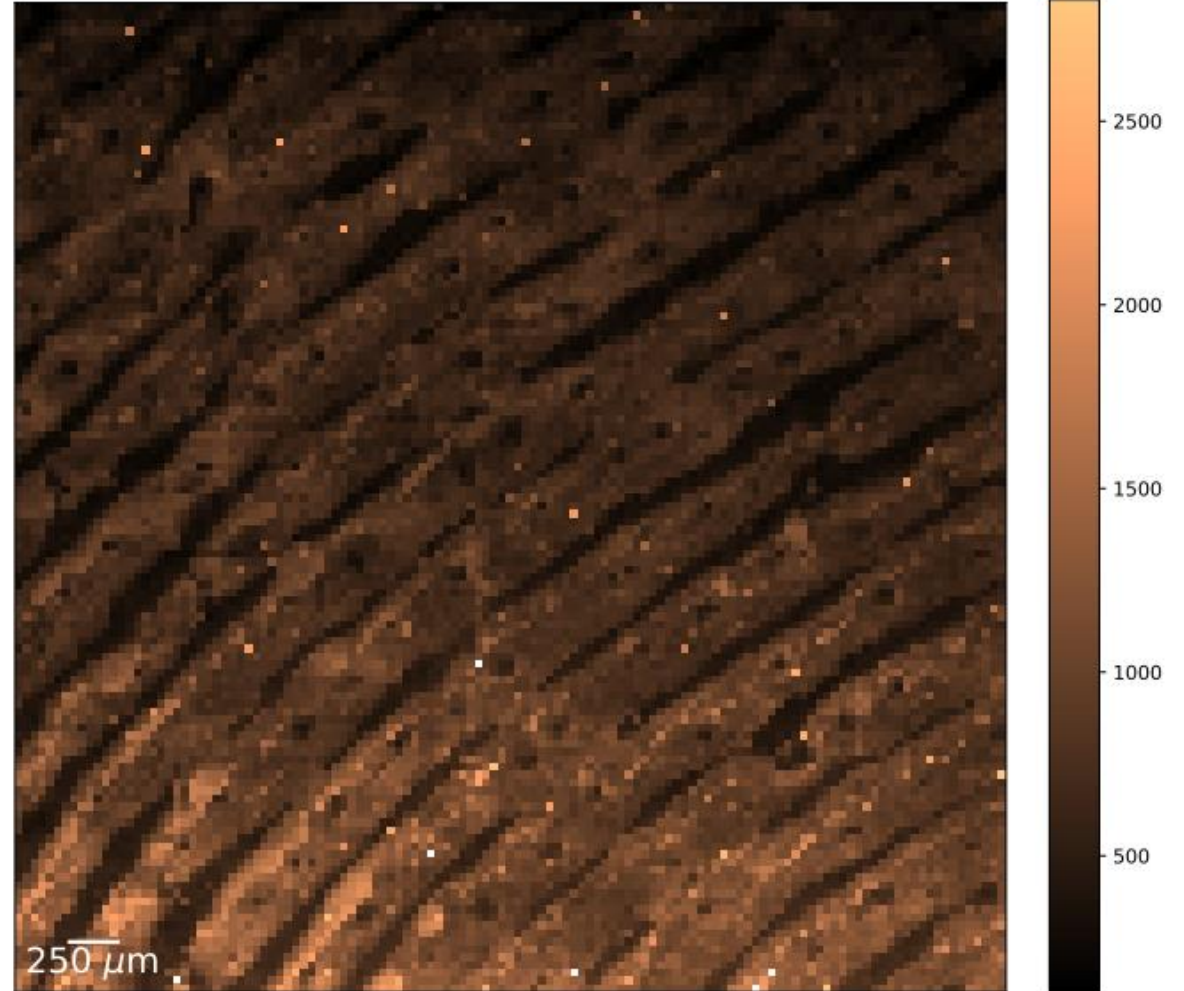


map of signature ink molecules (358-372 Da),
ink crossing on a paper, 1 x 1 mm²

IMAGING #3: FINGERMARK



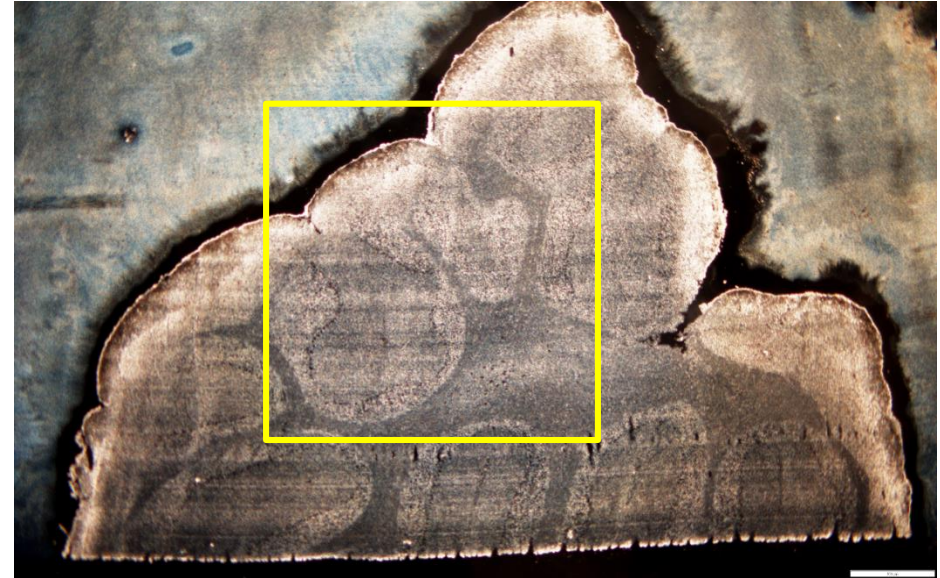
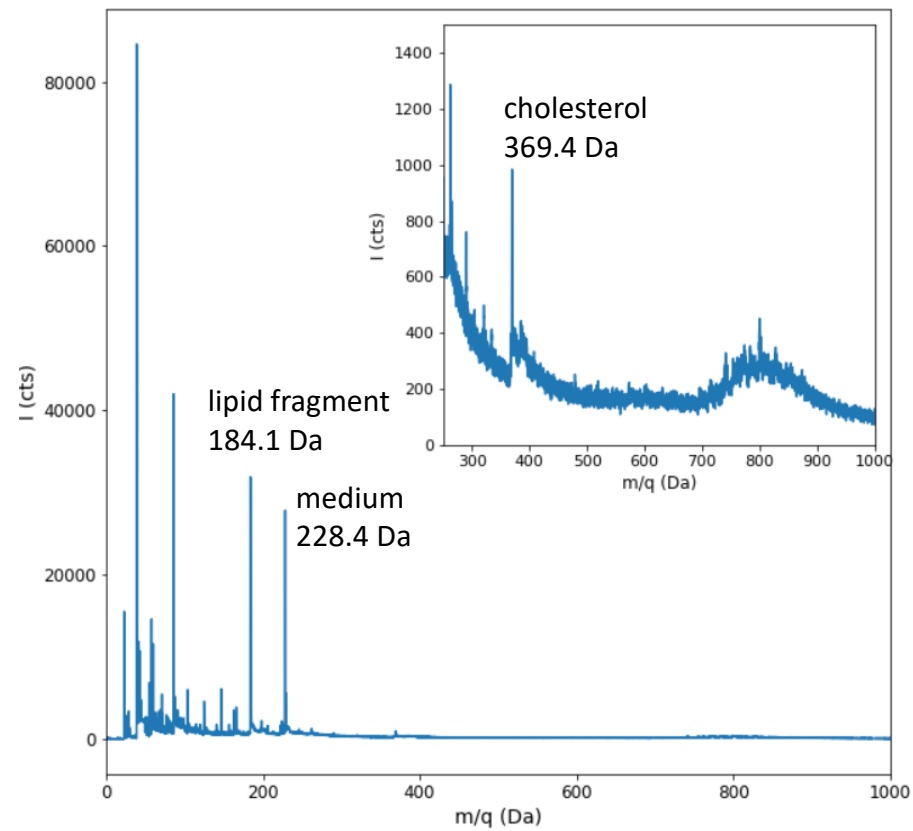
fingerprint on a silicon plate
under optical microscope



total map, fingerprint on a silicon
plate, 5 x 5 mm²

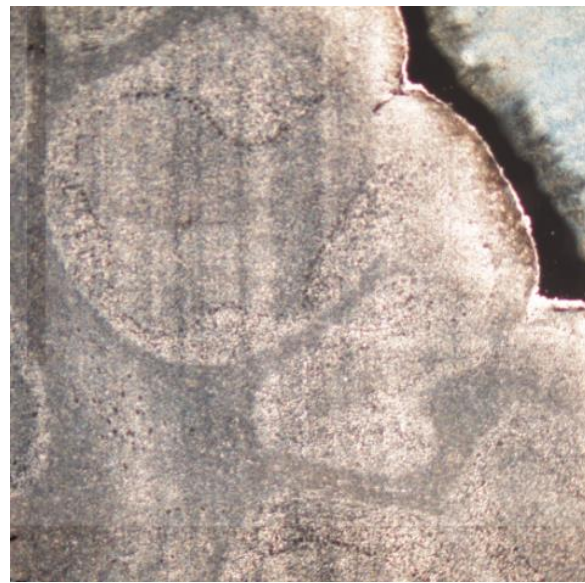
IMAGING #4: MOUSE TISSUE

2 x 2 mm² scan,
t = 3.5 hours

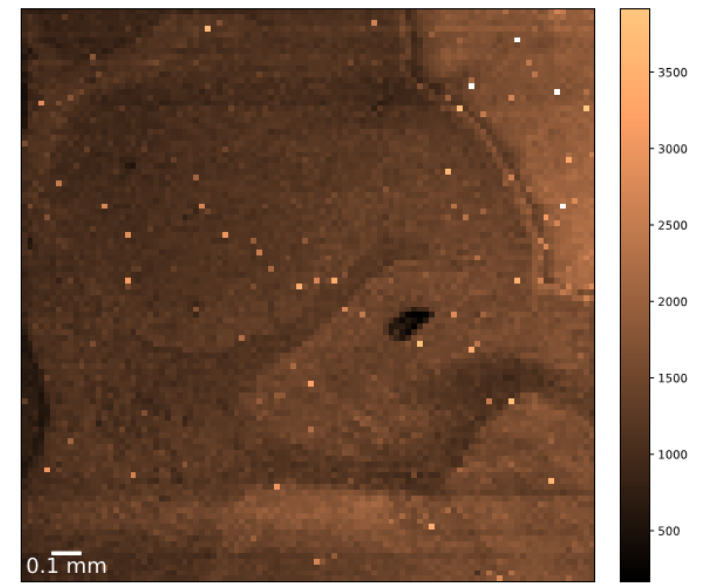


primary beam 14 MeV Cu⁴⁺

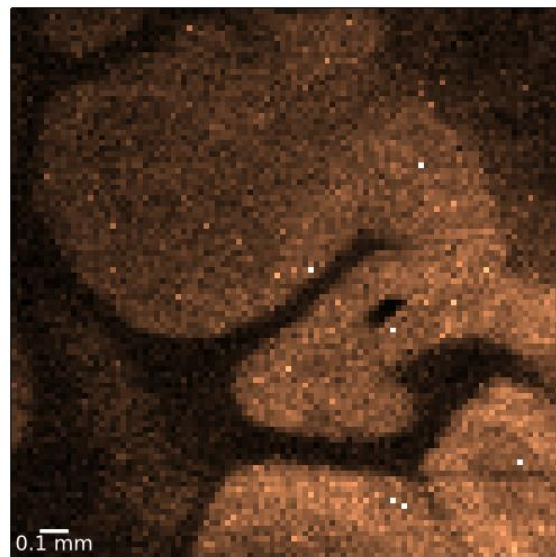
IMAGING #4: MOUSE TISSUE



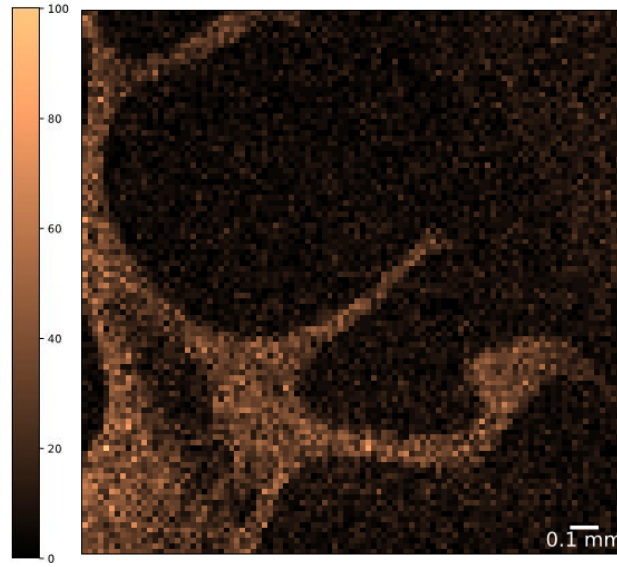
sample photo on an optical microscope



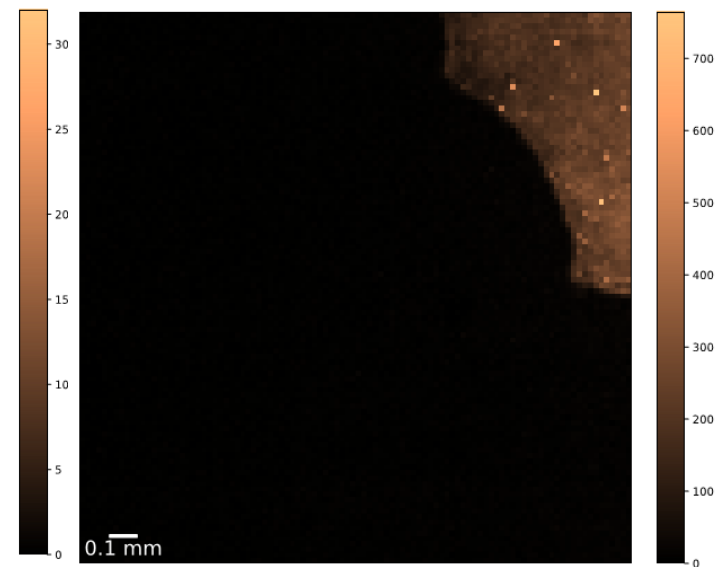
total map



lipid fragment ($m = 184.1$ Da)



cholesterol ($m = 369.4$ Da)



medium ($m = 228.4$ Da)

CONCLUSIONS

- Two techniques (heavy MeV ions + TOF measurements): inorganic films and organic samples
- Different applications: thin film analysis, biomedicine, forensics, ...

THANK YOU FOR LISTENING!

Acknowledgments

